

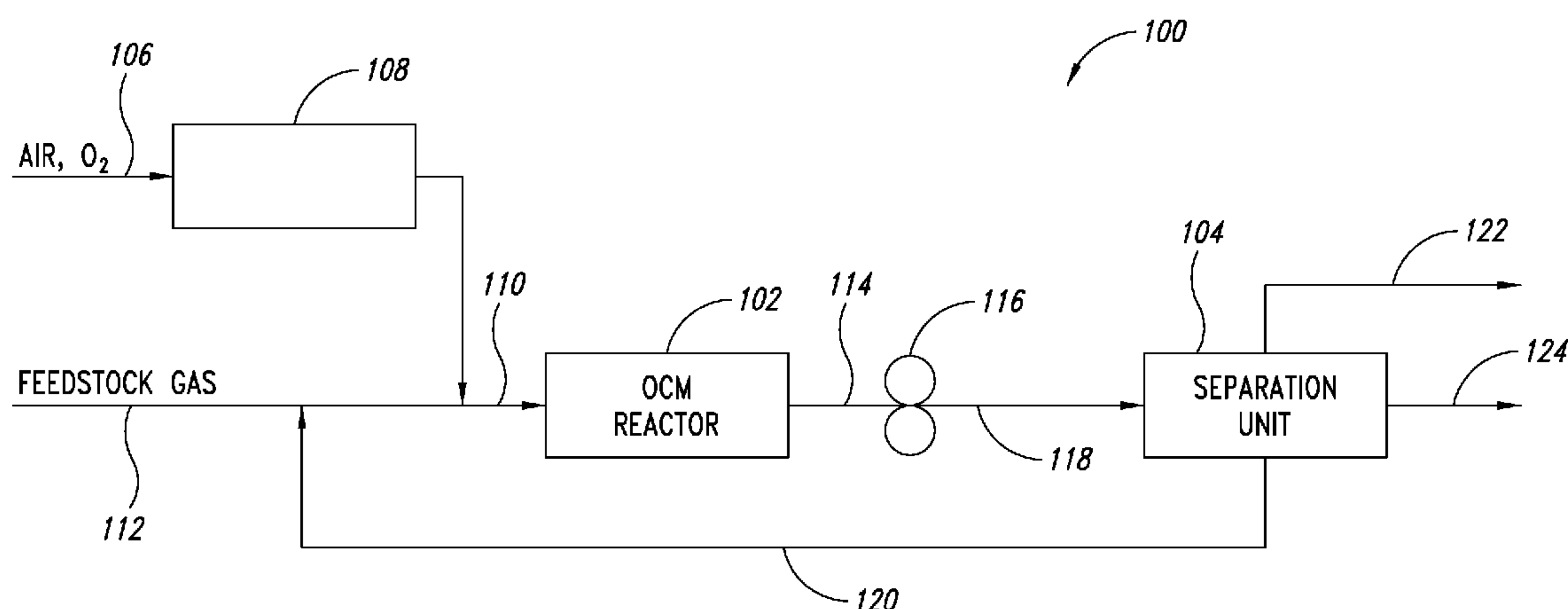
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Weinberger et al.(10) **Pub. No.: US 2017/0275217 A1**(43) **Pub. Date: Sep. 28, 2017**(54) **PROCESS FOR SEPARATING
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Rahmim, San Francisco, CA (US)(21) Appl. No.: **15/354,886**(22) Filed: **Nov. 17, 2016****Related U.S. Application Data**(63) Continuation of application No. 14/820,460, filed on
Aug. 6, 2015, now Pat. No. 9,527,784, which is a
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F25J 3/0257 (2013.01); **F25J 2205/04**
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(2013.01)

(57)

ABSTRACT

Disclosed herein are processes for producing and separating ethane and ethylene. In some embodiments, an oxidative coupling of methane (OCM) product gas comprising ethane and ethylene is introduced to a separation unit comprising two separators. Within the separation unit, the OCM product gas is separated to provide a C₂-rich effluent, a methane-rich effluent, and a nitrogen-rich effluent. Advantageously, in some embodiments the separation is achieved with little or no external refrigeration requirement.



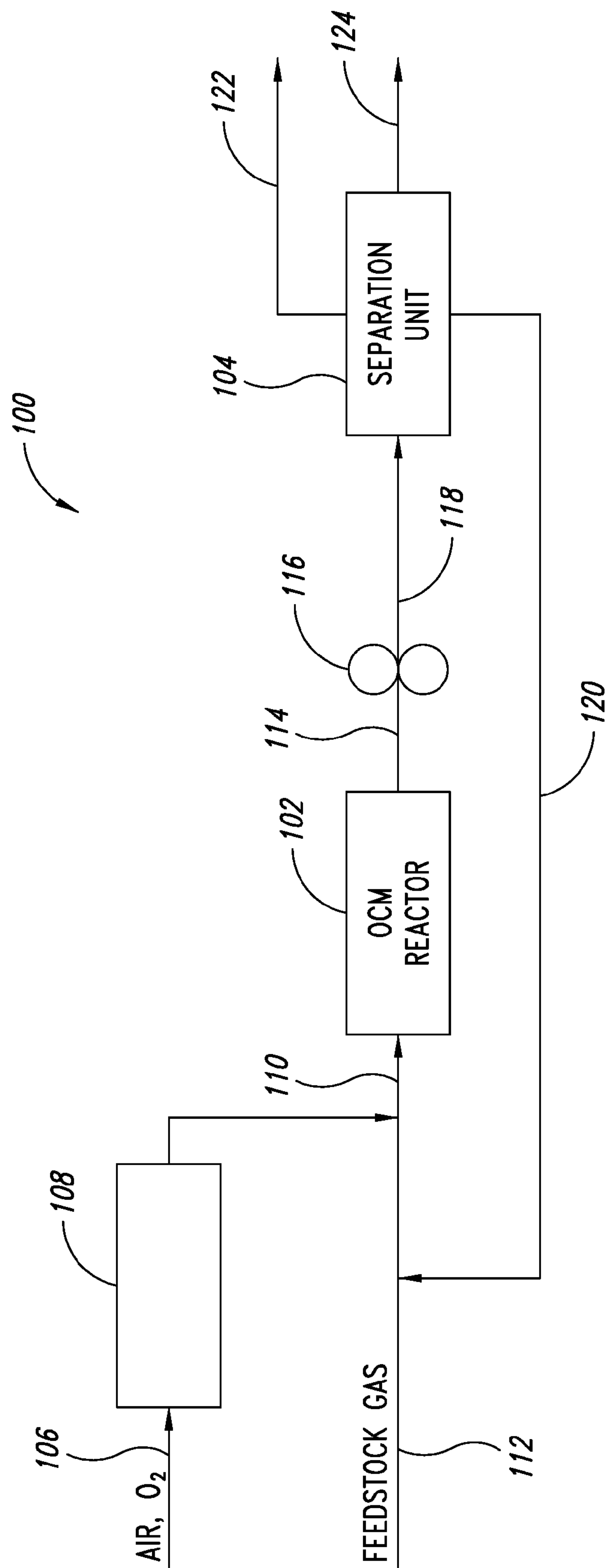


FIG. 1

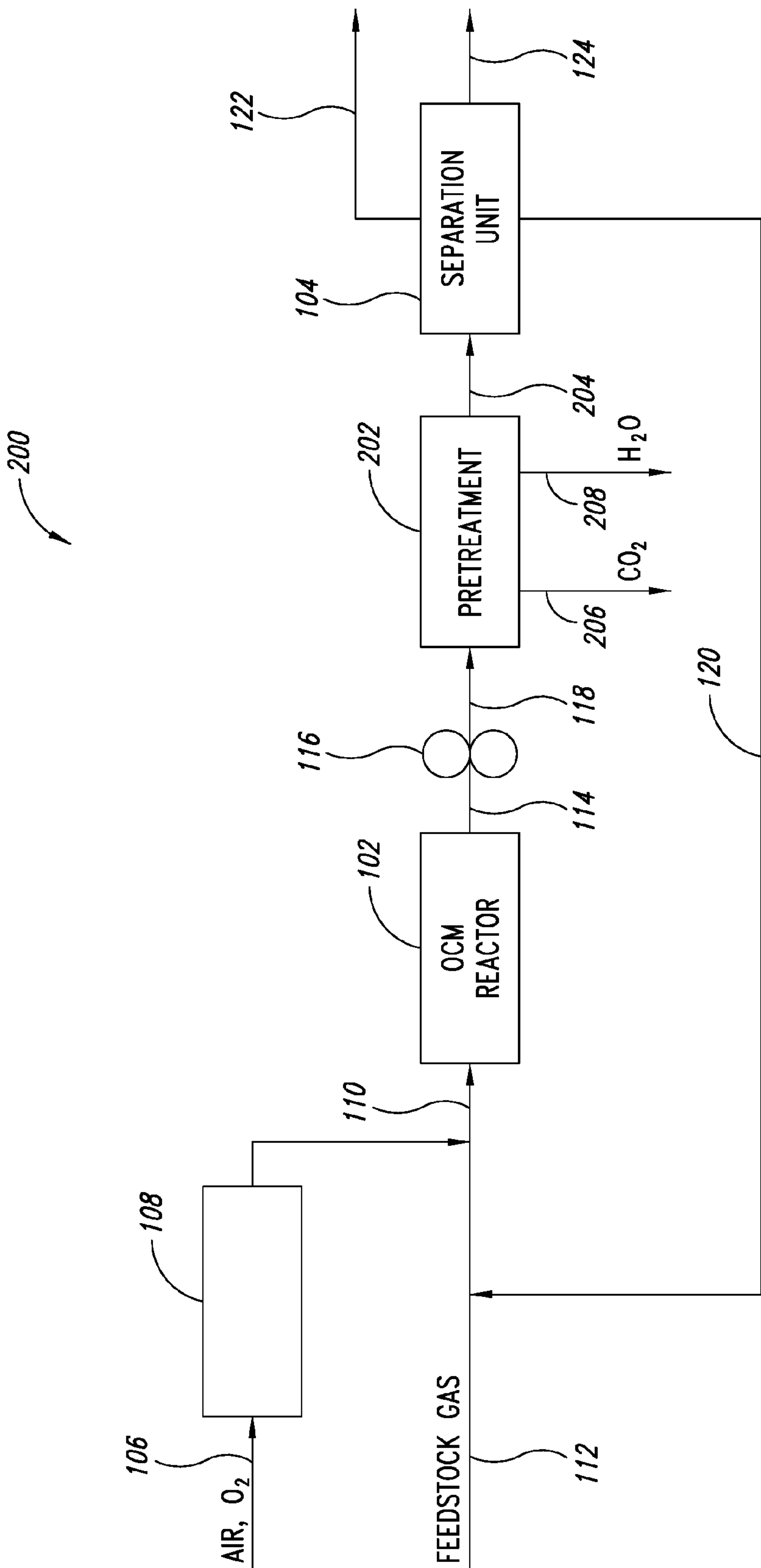


FIG. 2

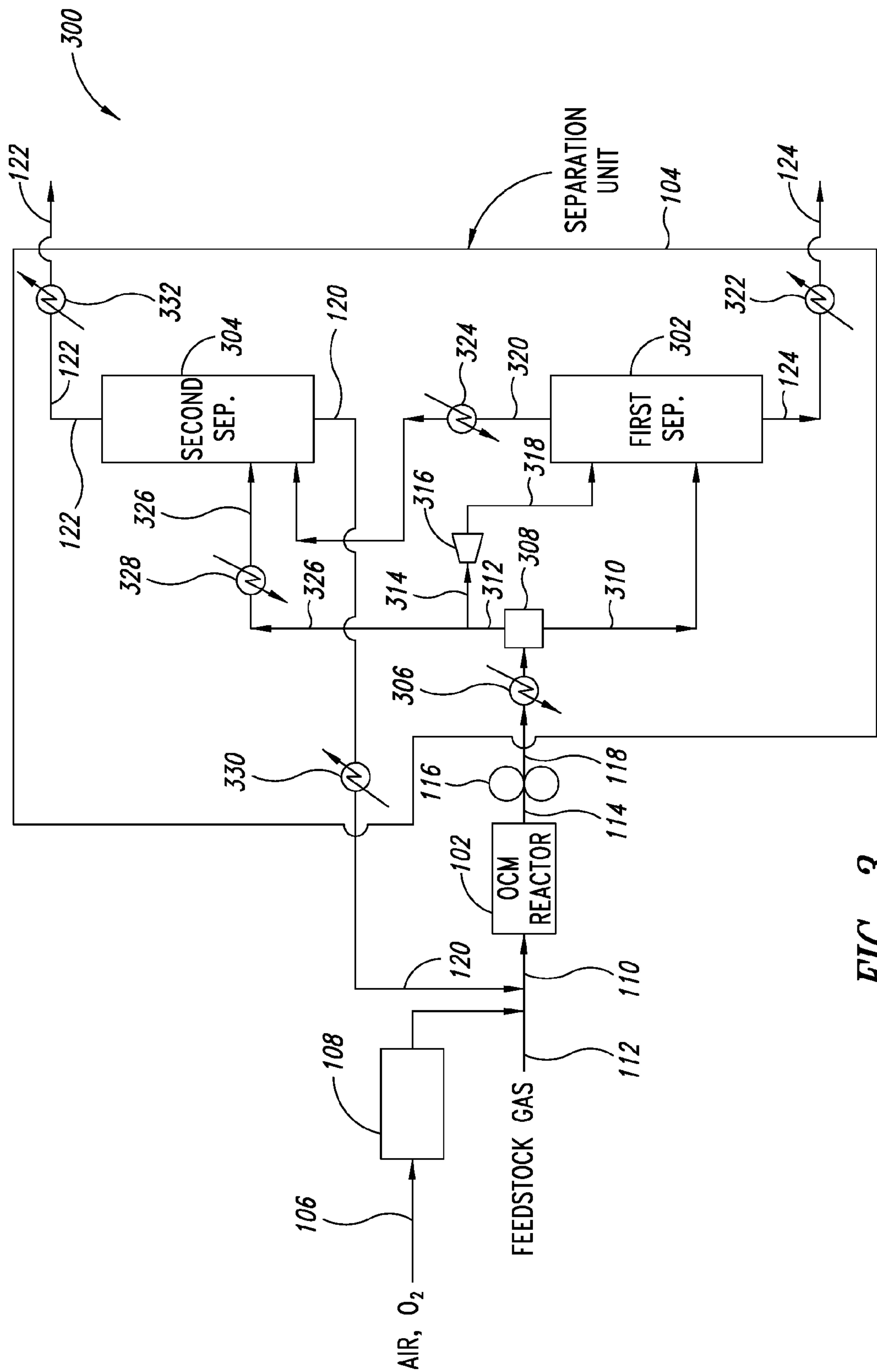


FIG. 3

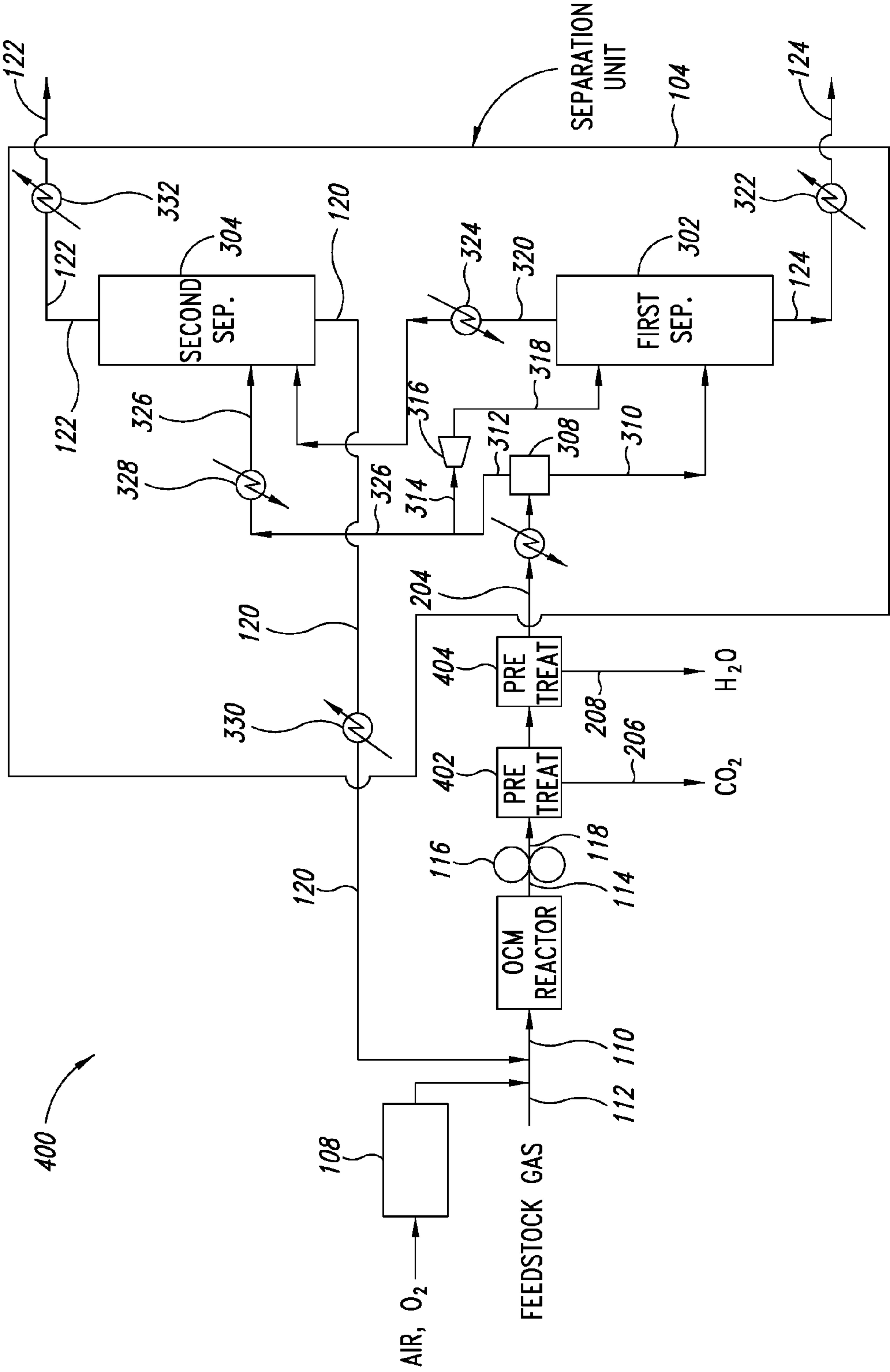


FIG. 4

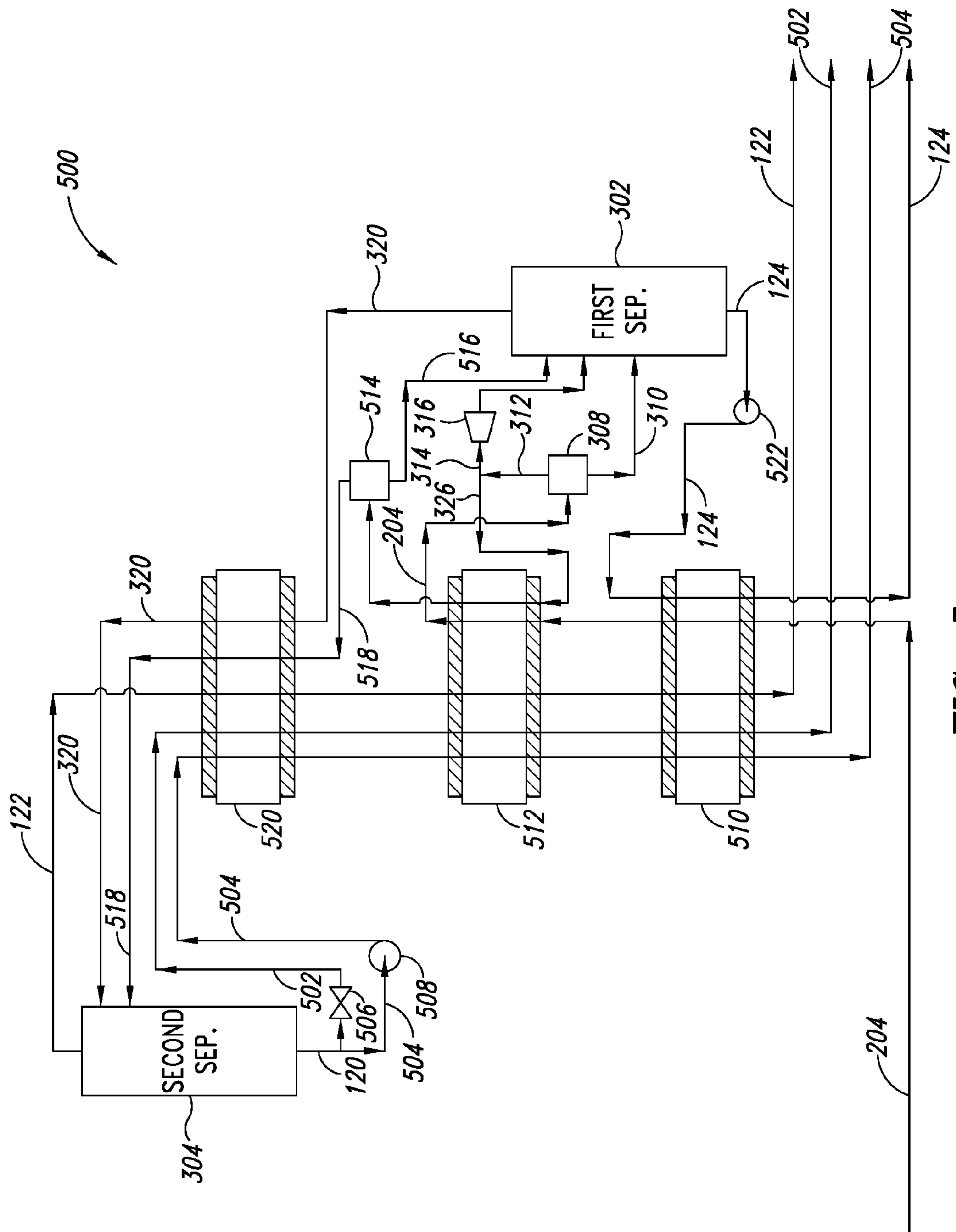


FIG. 5

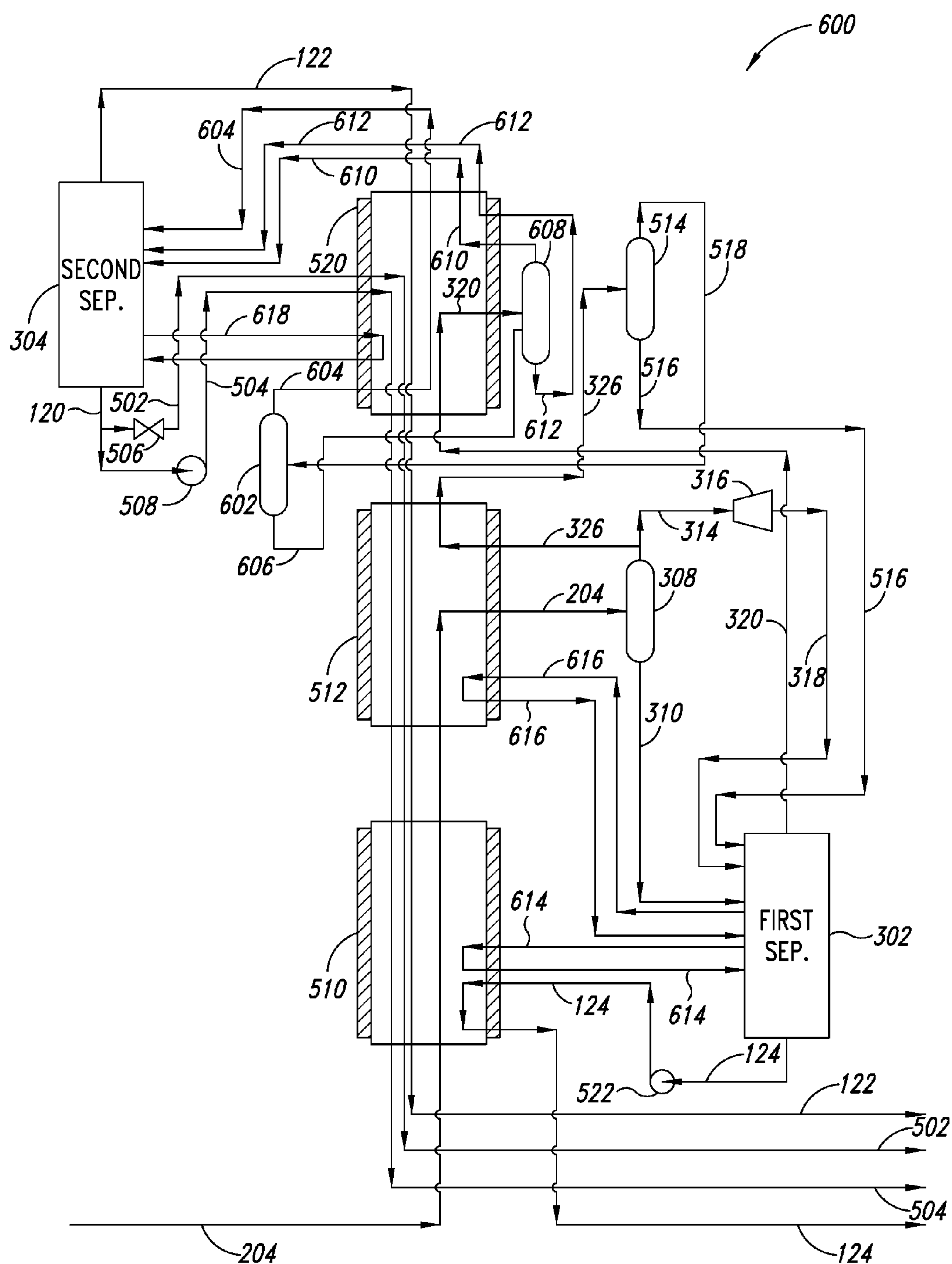


FIG. 6

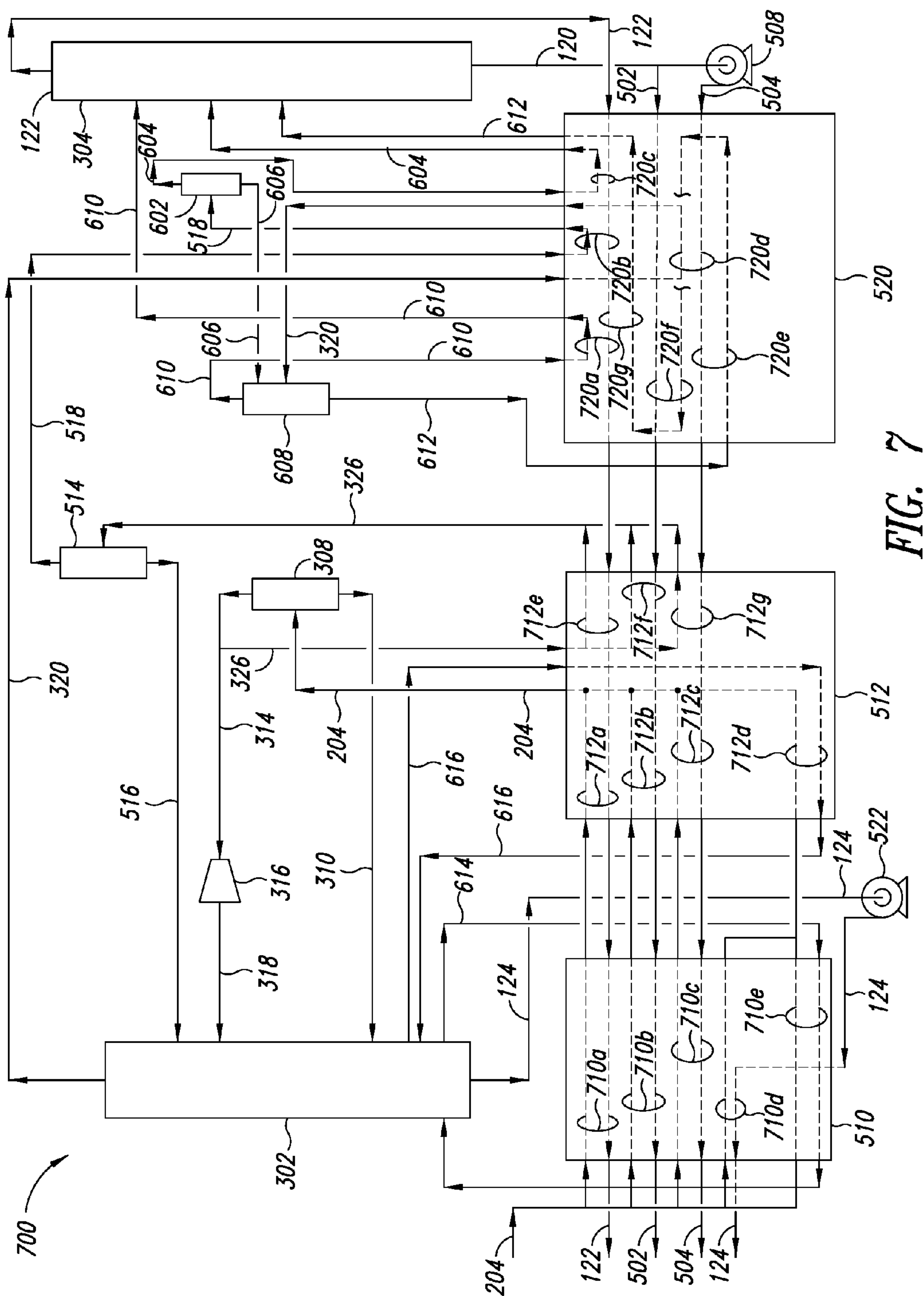


FIG. 7

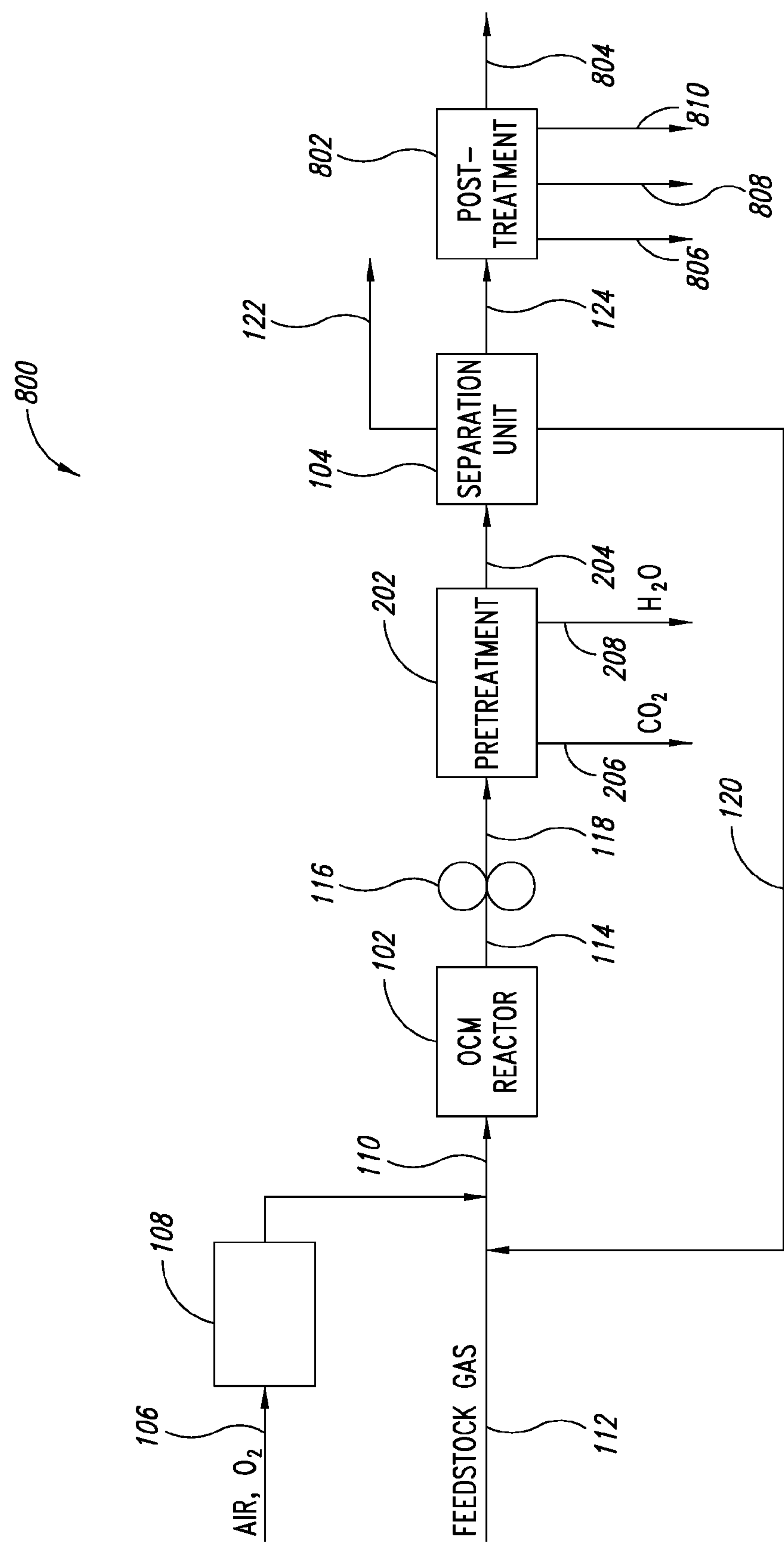


FIG. 8

PROCESS FOR SEPARATING HYDROCARBON COMPOUNDS

CROSS REFERENCE

[0001] This application is a continuation application of U.S. patent application Ser. No. 14/820,460, filed Aug. 6, 2015, which is a continuation application of U.S. patent application Ser. No. 13/739,954, filed Jan. 11, 2013, now U.S. Pat. No. 9,133,079, which claims the benefit of U.S. Provisional Patent Application Ser. No. 61/586,711, filed Jan. 13, 2012, each of which is incorporated herein by reference in its entirety.

BACKGROUND

[0002] Technical Field

[0003] This disclosure generally relates to selectively separating carbon compounds containing at least two carbon atoms from a mixed gas stream provided by a chemical process.

[0004] Description of the Related Art

[0005] The modern petrochemical industry makes extensive use of cracking and fractionation technology to produce and separate various desirable compounds from crude oil. Cracking and fractionation operations are energy intensive and generate considerable quantities of greenhouse gases. The gradual depletion of worldwide petroleum reserves and the commensurate increase in petroleum prices places extraordinary pressure on refiners to minimize losses and improve efficiency when producing products from existing feedstocks, and also to seek viable alternative feedstocks capable of providing affordable hydrocarbon intermediates and liquid fuels to downstream consumers.

[0006] Methane provides an attractive alternative feedstock for the production of hydrocarbon intermediates and liquid fuels due to its widespread availability and relatively low cost when compared to crude oil. Worldwide methane reserves are estimated in the hundreds of years at current consumption rates and new production stimulation technologies promise to make formerly unattractive methane deposits commercially viable.

[0007] Used in the production of polyethylene plastics, polyvinyl chloride, ethylene oxide, ethylene chloride, ethylbenzene, alpha-olefins, linear alcohols, vinyl acetate, and fuel blendstocks such as but not limited to aromatics, alkanes, alkenes, ethylene is one of the most important commodity chemical intermediates currently produced. With economic growth in developed and developing portions of the world, demand for ethylene and ethylene based derivatives continues to increase. Currently, ethylene production is limited to high volume production as a commodity chemical in a relatively large steam cracker or other petrochemical complex setting due to the high cost of the crude oil feedstock and the large number of hydrocarbon byproducts generated in the crude oil cracking process. Producing ethylene from far more abundant and significantly less expensive natural gas provides an attractive alternative to ethylene derived from crude oil. Oligomerization processes can be used to further convert ethylene into longer chain hydrocarbons such as C_6 and C_8 hydrocarbons useful for polymer gasoline and high value specialty chemicals.

[0008] The conversion of methane to longer chain hydrocarbons, particularly alkenes such as ethylene, produces a

product gas containing multiple byproducts, unreacted feedstock gases, and inert components in addition to ethylene. The ability to selectively and economically produce and separate methane based alkenes on a commercially viable scale provides a pathway to a significant new source of ethylene useful for production of ethylene based derivatives.

BRIEF SUMMARY

[0009] As noted above, the present disclosure is directed to methods for providing C_2 carbon compounds via oxidative coupling of methane (OCM). The methods may be summarized as including steps of:

[0010] a) combining a feedstock gas comprising methane with an oxygen containing gas comprising oxygen;

[0011] (b) contacting the combined feedstock gas and oxygen containing gas with a catalyst and providing an OCM product gas comprising ethane and ethylene (C_2);

[0012] (c) compressing the OCM product gas;

[0013] (d) condensing at least a portion of the OCM product gas to provide an OCM product gas condensate comprising mostly water;

[0014] (e) introducing the OCM product gas condensate to a first separator;

[0015] (f) isentropically expanding and reducing the temperature of a first portion of the OCM product gas;

[0016] (g) introducing the first portion of the OCM product gas to the first separator and introducing a second portion of the OCM product gas to a second separator, the second separator operating at a lower pressure and temperature than the first separator;

[0017] (h) removing a C_2 -rich effluent and a methane/nitrogen containing gas mixture from the first separator;

[0018] (i) introducing the methane/nitrogen containing gas mixture to the second separator; and

[0019] (j) removing a methane-rich effluent and a nitrogen-rich effluent from the second separator.

[0020] In certain embodiments of the disclosed methods, the oxygen containing gas is compressed air having an oxygen content of about 21 mol % and a nitrogen content of about 78 mol %; and the nitrogen content in the methane/nitrogen containing gas removed from the first separator may be at least about 85 mol %. In yet other embodiments, the first and second separators may operate at a below ambient temperature; and adiabatic expansion of at least one of the OCM product gas, a methane gas, a nitrogen gas, or a methane/nitrogen gas mixture may provide at least a portion of the cooling to produce the below ambient temperature. In other embodiments, the oxygen containing gas is compressed oxygen having an oxygen content of at least about 90 mol % and a nitrogen content of at most about 10 mol %; and the nitrogen content in the methane/nitrogen containing gas removed from the first separator may be at most about 85 mol %. In yet other embodiments, the first and second separators may operate at a below ambient temperature; and the compressed oxygen may be supplied via a cryogenic process and the cryogenic process may provide at least a portion of the cooling to produce the below ambient temperature.

[0021] Methods for providing C_2 carbon compounds via oxidative coupling of methane (OCM) in accordance with embodiments described herein may further include introducing at least a portion of the methane-rich effluent removed from the second separator to the feedstock gas prior to combining the feedstock gas with the oxygen

containing gas. In certain embodiments, the C₂-rich effluent may include at least about 90.0 mol % C₂, the methane-rich effluent may include at least about 92.0 mol % methane, and the nitrogen-rich effluent may include at least about 85.0 mol % nitrogen.

[0022] In other embodiments disclosed herein, methods for providing C₂ carbon compounds via oxidative coupling of methane (OCM) may further include reducing water content in the OCM product gas to about 0.001 mol % at most prior to condensing at least a portion of the OCM product gas.

[0023] Methods for providing C₂ carbon compounds via oxidative coupling of methane (OCM) in accordance with disclosed embodiments may further include reducing carbon dioxide content in the OCM product gas to about 5 ppm at most prior to condensing at least a portion of the OCM product gas.

[0024] Other embodiments of methods for providing C₂ carbon compounds via oxidative coupling of methane (OCM) may further include reducing hydrogen sulfide content in the feedstock gas to about 5 ppm. In certain embodiments disclosed herein, the feedstock gas may include at least about 20 mol % methane and compressing the OCM product gas may include increasing the pressure of the OCM product gas to at least about 100 pounds per square inch gauge (psig).

[0025] In another aspect of the disclosed subject matter processes for separating C₂ compounds from a product of an oxidative coupling of methane (OCM) process may be summarized as including:

[0026] (a) providing an OCM product gas from an OCM process, the OCM product gas comprising ethane and ethylene;

[0027] (b) compressing the OCM product gas to a pressure of at least about 200 pounds per square inch gauge (psig);

[0028] (c) reducing the temperature of the OCM product gas and condensing at least a portion of the OCM product gas to provide an OCM product gas condensate;

[0029] (d) separating the OCM product gas condensate from the OCM product gas;

[0030] (e) introducing the OCM product gas condensate to a first separator;

[0031] (f) separating the OCM product gas separated from the OCM product gas condensate into a first portion and a second portion and isentropically expanding the first portion of the OCM product gas through a turboexpander to reduce the temperature of the first portion of the OCM product gas;

[0032] (g) introducing the first portion of the OCM product gas to the first separator;

[0033] (h) removing a C₂-rich effluent from the first separator;

[0034] (i) removing a first separator overhead gas from the first separator;

[0035] (j) reducing the temperature of the first separator overhead gas;

[0036] (k) introducing the cooled first separator overhead gas to a second separator;

[0037] (l) removing a methane-rich effluent from the second separator; and

[0038] (m) removing a nitrogen-rich effluent from the second separator.

[0039] In additional embodiments of the present disclosure, methods for separating C₂ compounds from a product of an oxidative coupling of methane (OCM) process may further include:

[0040] (n) reducing the temperature of the second portion of the OCM product gas;

[0041] (o) adiabatically expanding the second portion of the OCM product gas to provide an at least partially condensed mixed stream that includes a second OCM product gas condensate and a second OCM product gas;

[0042] (p) introducing the at least partially flashed second OCM product gas condensate to the first separator; and

[0043] (q) reducing the temperature of the second OCM product gas and introducing the second OCM product gas to the second separator.

[0044] Methods for separating C₂ compounds from a product of an oxidative coupling of methane (OCM) process in accordance with disclosed embodiments of this aspect of the present disclosure may further include reducing water concentration in the OCM product gas to about 0.001 mole percent (mol %) at most and more preferably to about 0.0001 mol % (1 ppmv) at most prior to condensing at least a portion of the OCM product gas.

[0045] In other embodiments, methods for separating C₂ compounds from a product of an oxidative coupling of methane (OCM) process may further include reducing carbon dioxide concentration in the OCM product gas to about 10 ppmv at most prior to condensing at least a portion of the OCM product gas.

[0046] In other embodiments, methods for separating C₂ compounds from a product of an oxidative coupling of methane (OCM) process may further include reducing acetylene concentration in the OCM product gas to about 1 part per million by volume (ppmv) at most prior to condensing at least a portion of the OCM product gas or reducing the acetylene concentration in a C₂-rich effluent provided by the separations unit to about 1 ppmv at most.

[0047] In accordance with other disclosed embodiments of this aspect of the present disclosure, methods for separating C₂ compounds from a product of an oxidative coupling of methane (OCM) process may further include reducing hydrogen sulfide concentration in the OCM process to about 5 ppm at most using sulfur removal process, system and/or device, such as a sulfur trap. In other embodiments, providing the OCM product gas may include combining compressed air comprising oxygen and nitrogen and having an oxygen concentration of at least about 21 mol % with a feedstock gas comprising methane and having a methane concentration of at least 50 mol % and introducing the combined compressed air and feedstock gas to at least one OCM reactor. In other embodiments, the OCM product gas may include about 90 mol % or less nitrogen and providing the OCM product gas may include combining an oxygen containing gas comprising compressed oxygen and having an oxygen concentration of at least about 90 mol % with a feedstock gas comprising methane and having a methane concentration of at least about 50 mol % and introducing the combined compressed oxygen and feedstock gas to at least one OCM reactor. In certain embodiments, the OCM product gas may include about 10 mol % or less nitrogen.

[0048] In yet other embodiments, the method for separating C₂ compounds from a product of an oxidative coupling of methane (OCM) process disclosed herein may further include recycling at least a portion of the methane-rich

effluent from the second separator to an OCM reactor. In other embodiments, the C₂-rich effluent may include at least about 90 mol % C₂, the methane-rich effluent may include at least about 60 mol % methane, and the nitrogen-rich effluent may include at least about 50 mol % nitrogen.

[0049] In yet another aspect of the disclosed subject matter, processes for separating C₂ compounds from a product of an oxidative coupling of methane (OCM) process may be summarized as including:

[0050] (a) combining a feedstock gas comprising methane with an oxygen containing gas;

[0051] (b) contacting the combined feedstock gas and oxygen containing gas with a catalyst and providing an OCM product gas having a C₂ concentration of from about 0.5 mol % to about 20 mol %, a methane content of about 60 mole percent (mol %) or less, and a nitrogen content of at least about 20 mol %;

[0052] (c) compressing the OCM product gas; and separating the OCM product gas into a C₂-rich effluent; a methane-rich effluent; and an nitrogen-rich effluent.

[0053] In accordance with embodiments of this aspect of the disclosed subject matter, separating the OCM product gas into the C₂-rich effluent; the methane-rich effluent; and the nitrogen-rich effluent may occur at a lower than ambient temperature. In addition, in accordance with disclosed embodiments, adiabatic expansion of at least one of the OCM product gas, a methane gas, a nitrogen gas, or a methane/nitrogen gas mixture may provide at least a portion of the cooling to achieve the lower than ambient temperature and in other embodiments of the disclosed subject matter, adiabatic expansion of at least one of the OCM product gas, a methane gas, a nitrogen gas, or a methane/nitrogen gas mixture may provide all of the cooling to achieve the lower than ambient temperature.

[0054] In other embodiments, processes for separating C₂ compounds from a product of an oxidative coupling of methane (OCM) process may further include recycling at least a portion of the methane-rich effluent and combining it with the feedstock gas and/or the oxygen containing gas. In other embodiments, the C₂+ rich effluent may include at least about 90 mol % C₂+ compounds, the methane-rich effluent may include at least about 60 mol % methane, and the nitrogen-rich effluent may include at least about 50 mol % nitrogen. In other embodiments, compressing the OCM product gas may include increasing the pressure of the OCM product gas to at least about 200 pounds per square inch gauge (psig).

[0055] In another aspect of the disclosed subject matter, processes for separating ethylene from a product of an oxidative coupling of methane (OCM) process may be summarized as including:

[0056] (a) reducing the hydrogen sulfide content of a feedstock gas comprising methane to about 5 ppm at most;

[0057] (b) combining the feedstock gas with an oxygen containing gas comprising oxygen;

[0058] (c) passing the combined feedstock gas and oxygen containing gas across a catalyst to provide an OCM product gas having an ethylene content of about 0.5 mol % or greater, a hydrogen content of from about 0.0 mol % to about 4.0 mol %, a methane content of about 95 mol % or less, and a nitrogen content of at least about 1 mol %;

[0059] (d) compressing the OCM product gas; and

[0060] (e) separating the OCM product gas into a ethylene-rich effluent; a methane-rich effluent; and an nitrogen-rich effluent.

[0061] In accordance with embodiments of this aspect of the disclosed subject matter, the OCM product gas exiting the OCM reactor may be at a temperature of no more than about 1750° F. (950° C.) or preferably no more than about 1650° F. (900° C.) and/or at a pressure of no more than 200 psig (690 kPa). In accordance with other embodiments, the catalyst may include a compound including at least one of an alkali metal, an alkaline earth metal, a transition metal, and a rare-earth metal.

[0062] In accordance with other embodiments, separating the OCM product gas into an ethylene-rich effluent; a methane-rich effluent; and a nitrogen-rich effluent may include:

[0063] (f) reducing the temperature of the OCM product gas and condensing at least a portion of the OCM product gas to provide an OCM product gas condensate;

[0064] (g) separating the OCM product gas condensate from the OCM product gas;

[0065] (h) introducing the OCM product gas condensate to a first separator;

[0066] (i) separating the OCM product gas separated from the OCM product gas condensate into a first portion and a second portion and isentropically expanding the first portion of the OCM product gas through a turboexpander to reduce the temperature of the first portion of the OCM product gas;

[0067] (j) introducing the first portion of the OCM product gas to the first separator;

[0068] (k) removing the ethylene-rich effluent from the first separator;

[0069] (l) removing a first separator overhead gas from the first separator;

[0070] (m) reducing the temperature of the first separator overhead gas;

[0071] (n) introducing the cooled first separator overhead gas to a second separator;

[0072] (o) removing the methane-rich effluent from the second separator; and

[0073] (p) removing the nitrogen-rich effluent from the second separator.

[0074] In accordance with other embodiments of this aspect of the present disclosure, processes for separating ethylene from a product of an oxidative coupling of methane (OCM) process may further include recycling at least a portion of the methane-rich effluent from the second separator to the reduced hydrogen sulfide content feedstock gas. In other embodiments, the nitrogen-rich effluent may include about 50 mole percent (mol %) or greater nitrogen concentration, the methane-rich effluent may include about 60 mol % or greater methane concentration, and the ethylene-rich effluent may include from about 10 mol % to about 60 mol % or greater ethylene concentration. In additional embodiments, separating the OCM product gas into the ethylene-rich effluent; the methane-rich effluent; and the nitrogen-rich effluent may occur at a lower than ambient temperature and adiabatic expansion of at least one of the OCM product gas, a methane gas, a nitrogen gas, or a methane/nitrogen gas mixture may provide at least a portion of the cooling to provide the lower than ambient temperature.

BRIEF DESCRIPTION OF THE SEVERAL VIEWS OF THE DRAWINGS

[0075] In the drawings, identical reference numbers identify similar elements or acts. The sizes and relative positions of elements in the drawings are not necessarily drawn to scale. For example, the shapes of various elements and angles are not drawn to scale, and some of these elements are arbitrarily enlarged and positioned to improve drawing legibility. Further, the particular shapes of the elements as drawn, are not intended to convey any information regarding the actual shape of the particular elements, and have been solely selected for ease of recognition in the drawings.

[0076] FIG. 1 is a block flow diagram depicting a methane based C_2 production and separation process, according to one illustrated embodiment;

[0077] FIG. 2 is a block flow diagram depicting a methane based C_2 production, treatment, and separation process, according to one illustrated embodiment;

[0078] FIG. 3 is a basic process flow diagram depicting a methane based C_2 production and separation process, according to one illustrated embodiment;

[0079] FIG. 4 is a basic process flow diagram depicting a methane based C_2 production, treatment and separation process, according to one illustrated embodiment;

[0080] FIG. 5 is a process flow diagram depicting a separation process useful for separating a mixed product gas stream resulting from a methane based C_2 production process, according to one illustrated embodiment;

[0081] FIG. 6 is a process flow diagram depicting another separation process useful for separating a mixed product gas stream resulting from a methane based C_2 production process, according to one illustrated embodiment;

[0082] FIG. 7 is a process flow diagram depicting a detail heat exchanging scheme of another separation process useful for separating a mixed product gas stream resulting from a methane based C_2 production process, according to one illustrated embodiment; and

[0083] FIG. 8 is a block flow diagram depicting another methane based C_2 production and separation process, according to one illustrated embodiment.

DETAILED DESCRIPTION

[0084] In the following description, certain specific details are set forth in order to provide a thorough understanding of various disclosed embodiments. However, one skilled in the relevant art will recognize that embodiments may be practiced without one or more of these specific details, or with other methods, components, materials, etc. In other instances, well-known structures associated with specific unit operations, such as fluid transport, heat transfer, mass transfer, thermodynamic processes, and mechanical processes, e.g., fluid transportation, filtration, evaporation, condensation, gas absorption, distillation, extraction, adsorption, drying, gas liquefaction, and refrigeration have not been shown or described in detail to avoid unnecessarily obscuring descriptions of the embodiments.

[0085] Unless the context requires otherwise, throughout the specification and claims which follow, the word “comprise” and variations thereof, such as, “comprises” and “comprising” are to be construed in an open, inclusive sense, that is as “including, but not limited to.”

[0086] Reference throughout this specification to “one embodiment” or “an embodiment” means that a particular

feature, structure or characteristic described in connection with the embodiment is included in at least one embodiment. Thus, the appearances of the phrases “in one embodiment” or “in an embodiment” in various places throughout this specification are not necessarily all referring to the same embodiment. Furthermore, the particular features, structures, or characteristics may be combined in any suitable manner in one or more embodiments.

[0087] As used in this specification and the appended claims, the singular forms “a,” “an,” and “the” include plural referents unless the content clearly dictates otherwise. It should also be noted that the term “or” is generally employed in its sense including “and/or” unless the content clearly dictates otherwise.

[0088] As used in the specification and the appended claims, references are made to a “feedstock gas.” It is understood that a feedstock gas may include any gas or gasified liquid containing methane and recognizable by one of ordinary skill in the art as being suitable for providing methane to a oxidative coupling of methane (OCM) reaction. As used in the specification and the appended claims, references are made to an “effluent.” It is understood that an effluent may include any material or compound either removed or intended for removal from a particular location. Additionally, references are made to compositions that are variously described as being “nitrogen-rich,” “methane-rich,” and “ C_2 -rich.” It should also be understood that the use of the suffix “-rich” indicates the compound or compounds having the greatest molar concentration within the composition. For example, a “nitrogen-rich effluent” describes an effluent where nitrogen has the greatest molar concentration. Similarly a “methane-rich gas” describes a gas where methane has the greatest molar concentration. As used in the specification and the appended claims, references are made to a “unit.” It is understood that a unit may include any number of individual or combined unit operations such as separation, heating, cooling, condensation, vaporization, and the like as recognizable by one of ordinary skill in the art as being suitable or beneficial for achieving the indicated results. For example a “separation unit” may have more than one physical separator and may also include multiple ancillary heating, cooling, condensation and vaporization unit operations to achieve the desired separation.

[0089] As used herein the terms “ C_2 ” and “ C_2 compounds” refer to alkane (i.e., ethane) and alkene (i.e., ethylene) hydrocarbons and not to alkyne (i.e., acetylene) hydrocarbons comprising 2 carbon atoms in their backbone. C_{2+} refer to 2 chain length hydrocarbons and higher hydrocarbon chain length comprising both alkanes and alkenes, e.g. propane and propylene. As used herein the term “ C_2 content” refers to the concentration of C_2 compounds (i.e., ethane+ethylene) present at the specified location.

[0090] The headings and Abstract of the Disclosure provided herein are for convenience only and do not interpret the scope or meaning of the appended claims or disclosed embodiments.

[0091] FIG. 1 is a block flow diagram depicting an illustrative C_2 production and separation process 100 including one or more oxidative coupling of methane (OCM) reactors 102 and one or more separation units 104. In process 100, the pressure of an oxygen containing gas 106 is increased, for example using one or more compressors 108, and the resultant higher pressure oxygen containing gas is combined with a feedstock gas 112 containing methane to provide a

feedstock gas/oxygen containing gas mixture **110**. The feedstock gas/oxygen containing gas mixture **110** is introduced to the one or more OCM reactors **102**. Within the one or more OCM reactors **102**, methane present in the feedstock gas and the oxygen present in the oxygen containing gas are passed over a catalyst promoting the formation of an OCM product gas **114** including ethylene and ethane. The OCM product gas **114** may also contain amounts of unreacted feedstock such as methane; inert compounds such as nitrogen; and byproducts such as hydrogen, water vapor, and various carbon oxides (CO_x).

[0092] In the embodiment of FIG. 1, the pressure of the OCM product gas **114** is increased, for example using one or more compressors **116** prior to introduction to the one or more separation units **104**. Within the one or more separation units **104**, at least three effluents are produced: a methane-rich effluent **120**, a nitrogen rich effluent **122**, and a C_2 -rich effluent **124**. At least a portion of the methane-rich effluent **120** may be recycled to the feedstock gas **112** or alternatively the methane-rich effluent **120** may not be recycled to the feedstock gas **112**. Recycling of methane-rich effluent **120** is beneficial since methane is the feedstock for the production of C_2 s, however recycling at least a portion of the methane-rich effluent **120** provides additional operational and economic benefits because the methane-rich effluent **120** can be utilized without having to meet the stringent requirements of a fungible product, for example a maximum nitrogen limit imposed on methane intended for injection into a natural gas transport or distribution systems.

[0093] The C_2 -rich effluent **124** contains the desired ethane and ethylene compounds as well as C_3 and heavier hydrocarbon compounds such as propane and propylene (i.e., C_{3+} compounds). In some instances the C_2 compounds, particularly the ethylene, present in the C_2 -rich effluent **124** can be separated, for example using a C_2 splitter to selectively separate ethylene from ethane, and marketed as a commodity chemical. In other instances, all or a portion of the ethylene can be introduced to one or more additional unit operations, for example an oligomerization process to create oligomers, such as C_6 (trimer) and C_8 (tetramer) compounds, useful for example in liquid fuel products.

[0094] The oxygen containing gas **106** can include any source of oxygen such as air, purified oxygen, or mixtures thereof. The oxygen containing gas **106** can be an enriched oxygen containing gas sourced partially or wholly from an air separation plant or an air separation unit. The pressure of the oxygen containing gas **106** may be increased, for example using one or more compressors **108**, to provide the higher pressure oxygen containing gas. In some embodiments, the temperature of the higher pressure oxygen containing gas can be adjusted, for example through the use of an intercooler and/or aftercooler installed and operated in conjunction with the one or more compressors **108**. The addition of stoichiometric quantities of oxygen to the one or more OCM reactors via the oxygen containing gas **106** can limit the formation of undesirable combustion byproducts such as CO_x within the one or more OCM reactors **102**. In some instances, the temperature of the oxygen containing gas **106** may be increased, for example by thermally contacting the oxygen containing gas **106** with one or more higher temperature gases or liquids, prior to mixing with the feedstock gas **112**.

[0095] The composition of the oxygen containing gas **106** can vary dependent upon the source of the gas. For example,

where air is used to provide the oxygen containing gas, an oxygen content of about 21 mol % and a nitrogen content of about 78 mol % is provided. In at least some implementations, one or more inert gases, such as nitrogen, argon, or helium may be present in trace or larger quantities in the oxygen containing gas **106**. Where purified oxygen is used to provide the oxygen containing gas, an oxygen content of greater than about 21 mol % is possible. The oxygen content of the oxygen containing gas **106** can be about 21 mol % or greater; about 40 mol % or greater; about 60 mol % or greater; or about 80 mol % or greater. Similarly, the nitrogen content of the oxygen containing gas **106** will vary dependent upon the source providing the oxygen containing gas **106**. The nitrogen content of the oxygen containing gas can be about 78 mol % or less; about 60 mol % or less; about 40 mol % or less; or about 20 mol % or less. In at least some implementations, the nitrogen content of the oxygen containing gas can be from about 5 mole percent (mol %) to about 95 mol %; about 10 mol % to about 90 mol %; about 15 mol % to about 85 mol %; about 20 mol % to about 80 mol %; or about 25 mol % to about 75 mol %. The pressure of the compressed oxygen containing gas **110** can vary. For example, the pressure of the compressed oxygen containing gas can be about 300 psig (2100 kPa) or less; about 200 psig (1400 kPa) or less; or more preferably about 100 psig (700 kPa) or less.

[0096] The feedstock gas **112** includes methane, all or a portion of which may include methane from relatively clean sources such as that available from a pipeline, commercial or industrial supply or distribution network. In some instances, all or a portion of the feedstock gas **112** may be sourced from so called “dirty” sources such as extracted natural gas that contains contaminants or impurities requiring removal prior to introducing the feedstock gas **112** to the one or more OCM reactors **102**. While in general, the use of a feedstock gas **112** having a known, fixed methane composition is preferred, gases having a variable methane composition may also be used to provide all or a portion of the feedstock gas **112**. Similarly, while the use of a feedstock gas **112** having a high methane content is preferred, gases having low methane content may also be used to provide all or a portion of the feedstock gas **112** provided any components detrimental to catalyst life, catalyst performance, or any components promoting undesirable side reactions or the formation of undesirable products are partially or completely removed prior to introducing the feedstock gas **112** to the one or more OCM reactors **102**. The methane content of the feedstock gas **112** can vary and be about 20 mol % or less, about 35 mol % or less, about 50 mol % or less, about 80 mol % or less; about 90 mol % or less; about 95 mol % or less; or about 99 mol % or less.

[0097] Contaminants present in the feedstock gas **112** can include heavier weight hydrocarbons, acid gases such as carbon dioxide and hydrogen sulfide, nitrogen, water vapor, natural gas condensate (“casinghead gasoline”), and mercury to name a few. The feedstock gas **112** can be pretreated using known techniques prior to introduction to the one or more OCM reactors **102** to remove some or all of the contaminants such as hydrogen sulfide and heavier weight hydrocarbons that are capable of promoting the formation of undesired reaction side- or by-products, and/or detrimentally affecting the performance of the OCM catalyst disposed within the one or more OCM reactors **102**. After treatment, the hydrogen sulfide content of the feedstock gas **112** can be

about 20 ppm or less; about 10 ppm or less; about 5 ppm or less; or about 1 ppm or less. After treatment the heavier weight hydrocarbons content of the feedstock gas **112** can be about 0.1 mol % or less; about 0.05 mol % or less; or about 0.01 mol % or less. Since the one or more OCM reactors **102** operate at an elevated temperature, the temperature of the feedstock gas **112** may be increased prior to mixing with the oxygen containing gas **106** to lessen the thermal input required to raise the temperature of the feedstock gas/oxygen containing gas mixture to the desired reaction temperature within the one or more OCM reactors **102**.

[0098] In at least some embodiments the temperature and/or pressure of the feedstock gas **112** can be adjusted prior to mixing with the oxygen containing gas **106** or introduction to the one or more OCM reactors **102**. The pressure and temperature of the feedstock gas **106** can vary. For example the pressure of the feedstock gas **112** can be about 150 psig (1035 kPa) or less; about 100 psig (690 kPa) or less; about 75 psig (520 kPa) or less; about 50 psig (345 kPa) or less; or about 30 psig (205 kPa) or less and the temperature of the feedstock gas **112** can be about 200° F. (93° C.) or less; about 150° F. (66° C.) or less; about 100° F. (38° C.) or about 30° F. (0° C.) or less.

[0099] The higher pressure oxygen containing gas may be introduced, mixed, or otherwise combined with the feedstock gas **112** either within the one or more OCM reactors **102** or prior to the entry of either, or both, the higher pressure oxygen containing gas and/or the feedstock gas **112** to the one or more OCM reactors **102**. The feedstock gas/oxygen containing gas mixture **110** can be treated to remove one or more contaminants prior to introduction to the one or more OCM reactors **102**. Contaminants present in the feedstock gas **112** may be detrimental to the OCM catalyst and/or the one or more OCM reactors **102** themselves and therefore the concentration of these contaminants is reduced prior to introducing the feedstock gas/oxygen containing gas mixture **110** to the one or more OCM reactors **102**. For example, elemental sulfur or hydrogen sulfide may be present in concentrations ranging from trace amounts to double-digit mol % quantities within feedstock gas sources, such as extracted natural gas. The presence of sulfur or hydrogen sulfide can promote the formation of corrosive sulfurous acid within the one or more OCM reactors **102** and therefore are most desirably removed from the feedstock gas **112**, oxygen containing gas **106** or the feedstock gas/oxygen containing gas mixture **110** prior to introducing the mixture to the one or more OCM reactors **102**. After removal of sulfur or hydrogen sulfide, the hydrogen sulfide content of the feedstock gas/oxygen containing gas mixture **110** can be about 20 ppm or less; about 10 ppm or less; about 5 ppm or less; or more preferably about 1 ppm or less.

[0100] Additionally, the temperature of the feedstock gas/oxygen containing gas mixture **110** may be adjusted prior to introducing the mixture to the one or more OCM reactors **102**. The temperature can be adjusted to a desired level to optimize the generation of preferred products such as ethylene within the one or more OCM reactors **102**. In some instances, the temperature of the feedstock gas/oxygen containing gas mixture **110** may be adjusted in conjunction with one or more pretreatment steps, for example desulfurization of the feedstock gas/oxygen containing gas mixture **110**. Prior to entering the one or more OCM reactors **102**, the temperature of the feedstock gas/oxygen containing gas mixture **110** can be about 1300° F. (700° C.) or less; about

1110° F. (600° C.) or less; about 930° F. (500° C.) or less; about 750° F. (400° C.) or less; about 570° F. (300° C.) or less; or about 400° F. (200° C.) or less.

[0101] The OCM reactor **102** can include any vessel, device, system or structure capable of converting at least a portion of the feedstock gas/oxygen containing gas mixture **110** into one or more C₂ compounds using an oxidative coupling of methane process. The one or more OCM reactors **102** can be one or more similar or dissimilar reactors or reactor types arranged in series or parallel processing trains. The OCM process may be carried out in different types of commercially available reactors including a fixed bed reactor where the combined methane/oxygen gas mixture is passed through a structured bed; a fluidized bed reactor where the combined methane/oxygen mixture is used to fluidize a solid catalyst bed; and a membrane type reactor where the combined methane/oxygen mixture passes through an inorganic catalytic membrane.

[0102] The OCM reaction ($2\text{CH}_4\text{O}_2 \rightarrow \text{C}_2\text{H}_4 + 2\text{H}_2\text{O}$) is exothermic ($\Delta H = -67$ kcal/mole) and generally requires very high temperatures (>700° C.). As a consequence, the OCM reactors **102** can be sized, configured, and/or selected based upon the need to dissipate the heat generated by the OCM reaction, for example in some embodiments, multiple, tubular, fixed bed reactors can be arranged in parallel to facilitate heat removal. In at least some embodiments, at least a portion of the heat generated within the one or more OCM reactors **102** can be recovered, for example the heat can be used to generate high pressure steam. Where co-located with processes requiring a heat input, at least a portion of the heat generated within the one or more OCM reactors **102** may be transferred, for example using a heat transfer fluid, to the co-located processes. Where no additional use exists for the heat generated within the one or more OCM reactors **102**, the heat can be released to the atmosphere, for example using a cooling tower or similar evaporative cooling device.

[0103] In other embodiments, the one or more OCM reactors **102** may include multiple adiabatic, fixed-bed, OCM reactors arranged in a cascaded series, where the OCM product gas generated by a first OCM reactor is removed and introduced to a second OCM reactor, subsequent cascaded OCM reactors can be similarly arranged. In at least some embodiments, the OCM product gas removed from each reactor may be cooled, for example in a horizontal or vertical tube boiler using boiler feed water to generate high pressure steam, prior to introduction to a subsequent OCM reactor. A multi-stage, cascaded OCM reactor arrangement advantageously provides the ability to control the thermal profile through each OCM reactor and through the entire cascaded OCM reactor series. The ability to provide independent reactor thermal profiling as well as thermal profiling throughout all of the cascaded reactors can improve catalyst performance and catalyst life as well as providing a degree of product selectivity in the OCM product gas **114**.

[0104] In addition to a parallel configuration, multiple OCM reactors **102** may be arranged in a serial configuration or even a combination of series and parallel configurations. In a multiple reactor configuration, the OCM reactors **102** can be similar or different in size, type, or design based at least in part on process conversion and heat transfer specifications.

[0105] Chemical conversion is a measure of the quantity of reactants converted via a chemical reaction. Chemical

selectivity is a measure of the quantity of a reactant converted to the desired product. For example, within the one or more OCM reactors, in addition to the desired ethylene, methane in the feedstock gas **112** will also be converted to undesirable or unwanted byproducts including, but not limited to, water vapor, oxides of carbon, and hydrogen. The ethylene selectivity of the one or more OCM reactors **102** is therefore a quantitative measure of their ability to convert methane in the feedstock gas **112** to ethylene in the OCM product gas **114**. Conversion and selectivity are dependent upon a multitude of factors, including but not limited to: reactor design, catalyst, and operating conditions.

[0106] Although other OCM catalysts can be disposed in at least a portion of the one or more OCM reactors **102**, in at least some embodiments, at least a portion of the OCM catalyst in at least a portion of the one or more OCM reactors can include one or more nanowire-based OCM catalysts such as those developed by Siluria Technologies Inc. (Palo Alto, Calif.) and described in: U.S. patent application Ser. No. 13/115,082, filed May 24, 2011, entitled “Nanowire Catalysts;” U.S. Provisional Patent Application Ser. 61/564,832, filed Nov. 29, 2011, entitled “Catalysts for Petrochemical Catalysis;” U.S. Provisional Patent Application Ser. No. 61/564,834, filed Nov. 29, 2011, entitled “Nanowire Catalysts;” and U.S. Provisional Patent Application Ser. 61/564,836, filed Nov. 29, 2011, entitled “Polymer Templated Nanowire Catalysts”, all of which are incorporated in their entirety by reference as if reproduced in their entirety herein. Using one or more nanowire based OCM catalysts within the one or more OCM reactors **102**, the selectivity of the catalyst in converting methane to desirable C₂ products can be about 10% or greater; about 20% or greater; about 30% or greater; about 40% or greater; about 50% or greater; about 60% or greater; about 65% or greater; about 70% or greater; about 75% or greater; about 80% or greater; or about 90% or greater.

[0107] The one or more OCM reactors **102** provide an OCM product gas **114**. Although variable based upon a multitude of process equipment, reactant and process conditions, the OCM product gas **114** can contain in addition to the desired and valued ethylene product: water vapor, methane, ethane, nitrogen, hydrogen, carbon oxides, small quantities of heavier hydrocarbons (hydrocarbons containing three or more carbon atoms), acetylene or inert compounds. In exemplary embodiments, the ethylene content of the OCM product gas **114** can be about 0.5 mol % or greater; about 1 mol % or greater; about 2 mol % or greater; about 5 mol % or greater; about or more preferably about 7 mol % or greater and the ethane content of the OCM product gas **114** can be about 0.5 mol % or greater; about 1 mol % or greater; about 2 mol % or greater; about 5 mol % or greater; or more preferably about 7 mol % or greater. In at least some implementations, one or more inert gases, such as nitrogen, argon, or helium may be present in trace or larger quantities in the OCM product gas **114**.

[0108] Considerable quantities of nitrogen can be present in the OCM product gas **114**, particularly where air is used to supply all or a portion of the oxygen containing gas **106**. Nitrogen is carried through the one or more OCM reactors **102** as an inert compound and may therefore appear at a relatively high concentration in the OCM product gas **114**. In contrast, the nitrogen content of the OCM product gas **114** can be relatively low when purified oxygen, for example oxygen supplied by an air separation unit, is used to provide

nearly all or all of the oxygen containing gas **106**. In exemplary embodiments, the nitrogen content of the OCM product gas **114** can be about 1 mol % or less; about 5 mol % or less; about 10 mol % or less; about 25 mol % or less; about 40 mol % or less; or about 60 mol % or less. As discussed more fully below, the nitrogen or similar chemically inert gases in the OCM product gas **114** can be used advantageously in the separation unit **104** to provide some or all of the cooling required to recover C₂ compounds from the OCM product gas **114**.

[0109] Hydrogen is liberated from the unsaturated hydrocarbons formed in the OCM reaction and may be present as a potential byproduct in the OCM product gas **114**. The hydrogen content of the OCM product gas **114** can be about 4 mol % or less; about 3 mol % or less; about 2 mol % or less; or more preferably about 1 mol % or less.

[0110] Carbon oxides, including carbon monoxide and carbon dioxide, form as a result of the complete combustion of a portion of the hydrocarbons within the feedstock gas **112**. Such combustion is an unintentional consequence of operating a high temperature hydrocarbon conversion process. In exemplary embodiments, the carbon oxide content of the OCM product gas **114** can be about 10 mol % or less; about 7 mol % or less; or more preferably about 5 mol % or less.

[0111] Within the one or more OCM reactors **102**, the conversion of methane to heavier hydrocarbons is less than 100%. As a consequence, unreacted methane will be present in the OCM product gas **114**. The quantity of methane within the OCM product gas will vary dependent upon the degree of conversion achieved within the one or more OCM reactors **102**. In exemplary embodiments, the methane content of the OCM product gas **114** can be about 95 mole percent (mol %) or less; about 90 mol % or less; about 80 mol % or less; about 70 mol % or less; about 60 mol % or less; about 40 mol % or less; about 30 mol % or less; about 20 mol % or less; or about 10 mol % or less.

[0112] Where air is used to provide at least a portion of the oxygen containing gas **106**, argon will accumulate due to the recycle of at least a portion of the non-condensable gas (principally nitrogen) from the separation unit **104** to the OCM reactors **102**. In at least some situations, the argon content of the OCM product gas **110** can be 0 mol % for pure oxygen feed, about 1 mol % or less; about 5 mol % or less.

[0113] The temperature and pressure of the OCM product gas **114** is dependent upon maintaining a temperature and pressure profile within the one or more OCM reactors **102** that favors ethylene production while disfavoring the production of less desirable or undesirable by-products. Upon exiting the one or more OCM reactors **102**, the OCM product gas **114** can be at a pressure of about 200 psig (1380 kPa) or less; about 150 psig (1035 kPa) or less; about 100 psig (690 kPa) or less; or more preferably about 50 psig (345 kPa) or less. Due to the exothermic nature of the OCM reaction, post-cooling, for example by passing the OCM product gas **114** across a boiler feedwater preheater proximate the one or more OCM reactors **102**. In exemplary embodiments, upon exiting the one or more OCM reactors **102**, the OCM product gas **114** can be at a temperature of about 1750° F. (950° C.) or less; about 1650° F. (900° C.) or less; about 1560° F. (850° C.) or less; about 1470° F. (800° C.) or less; about 1380° F. (750° C.) or less; about 1300° F. (700° C.) or less; about 1100° F. (590° C.) or less; about

900° F. (480° C.) or less; about 700° F. (370° C.) or less; or about 500° F. (260° C.) or less.

[0114] Upon exiting the one or more OCM reactors **102**, the OCM product gas **114** is at a relatively high temperature and a relatively low pressure. Recalling that the presence of one or more inert gasses (e.g., nitrogen) within the OCM product gas **114** can be used advantageously to reduce the temperature within the separation unit **104**, the pressure of the OCM product gas **114** may also be increased using the one or more compressors **116** to provide a compressed OCM product gas **118**. The temperature of the OCM product gas **114** may be adjusted using one or more pre-coolers (not shown) prior to introducing the OCM product gas **114** to the one or more compressors **116**. The temperature of the compressed OCM product gas **118** may be reduced using one or more inter- or after-coolers after introducing the OCM product gas **114** to the one or more compressors **116**. After exiting the one or more compressors **116**, in exemplary embodiments the temperature of the compressed OCM product gas **118** can be about 150° F. (65° C.) or less; about 125° F. (52° C.) or less; about 100° F. (38° C.) or less; or about 75° F. (24° C.) or less. After exiting the one or more compressors **116**, in exemplary embodiments the pressure of the compressed OCM product gas **118** can be at least about 100 psig (690 kPa); at least about 150 psig (1035 kPa); at least about 200 psig (1380 kPa); at least about 250 psig (1725 kPa); or at least about 300 psig (2070 kPa).

[0115] The compressed OCM product gas **118** may be introduced to the separation unit **104**. Within the separation unit **104**, the mixed gasses within the compressed OCM product gas **118** are separated to provide the methane rich effluent **120**, the nitrogen rich effluent **122**, and the C₂-rich effluent **124**. In at least some embodiments, the separation unit can use in whole or in part, a cryogenic separation process to provide the methane rich effluent **120**, the nitrogen rich effluent **122**, and the C₂-rich effluent **124**.

[0116] Acetylene may be present in the OCM product gas at concentrations of up to about 0.1 mole percent (mol %); about 0.2 mol %; about 0.3 mol %; about 0.4 mol %; about 0.5 mol %; or about 0.75 mol %. All or a portion of any acetylene present in the OCM product gas **114** may be removed from the OCM product gas **114**. In at least some instances, at least a portion of any acetylene present in the OCM product gas **114** may be converted to at least one more preferable chemical species. For example, at least a portion of any acetylene present in the OCM product gas **114** may be converted to ethylene by passing all or a portion of the OCM product gas **114** through an acetylene reactor where the acetylene is catalytically, selectively, hydrogenated. In another implementation, at least a portion of any acetylene present may be fully hydrogenated to provide ethane. In yet another implementation, at least a portion of any acetylene present may be removed from the OCM product gas **114** and destroyed, for example via thermal combustion or oxidation in a controlled environment or via flare.

[0117] The gases in at least a portion of the compressed OCM product gas **118** may be adiabatically expanded to provide at least a portion of the cooling used in the cryogenic processes within the separation unit **104**. In some embodiments, at least a portion of the gasses within the separation unit **104** may be recompressed and re-adiabatically expanded to provide additional cooling and, potentially, obviate the need for external refrigeration within the separation unit **104**. Additionally, in some instances, at least a

portion of the gasses within the separation unit **104** may be isentropically expanded, for example using a turboexpander, to provide mechanical work (e.g., a shaft output) useful within the separation unit **104**.

[0118] Within the separation unit **104**, heavier hydrocarbon compounds, including ethane and ethylene are separated from the OCM product gas **118** to provide the C₂-rich effluent **124** and a mixed nitrogen/methane containing gas. In some implementations, any acetylene present in the OCM product gas **118** may be at least partially removed using one or more systems, devices, or processes included in the separation unit **104**. In other implementations, any acetylene present in the OCM Product gas **118** may be at least partially converted to one or more preferable chemical species using one or more systems, devices, or processes included in the separation unit **104**. For example, all or a portion of the OCM product gas **118** or the C₂-rich effluent **124** may be passed through an acetylene reactor where at least a portion of the acetylene present in the OCM product gas **118** or the C₂-rich effluent **124** is selectively, catalytically hydrogenated to ethylene. Such acetylene removal or conversion may occur at any point in the separation unit **104**, including preparatory to performing any separations (e.g., removal from the OCM product gas **118**), after completion of the separations (e.g., removal from the C₂-rich effluent **124**), at an intermediate stage of the separations process, or any combination thereof.

[0119] The mixed nitrogen/methane containing gas can be separated in separation unit to provide the nitrogen-rich effluent **122** and the methane-rich effluent **120**. At least a portion of the methane-rich effluent **120** can be recycled back to the feedstock gas **112** or to the one or more OCM reactors **102**. The methane-rich effluent **120** consists primarily of methane with other compounds present in small quantities. In exemplary embodiments, the methane content of the methane-rich effluent **120** can be about 60 mole percent (mol %) or greater; 80 mol % or greater; about 85 mol % or greater; about 90 mol % or greater; or more preferably about 95 mol % or greater. As explained above, the quantity and the concentration of nitrogen in the nitrogen-rich effluent **122** can depend upon the source used to supply the oxygen containing gas **106**. In exemplary embodiments, the nitrogen content of the nitrogen-rich effluent **122** can be about 50 mol % or greater; about 75 mol % or greater; about 85 mol % or greater; or more preferably about 90 mol % or greater. The C₂-rich effluent **124** contains ethane, ethylene, and higher molecular weight hydrocarbons. In exemplary embodiments, the ethane content of the C₂-rich effluent **124** can be about 10 mol % or greater; about 20 mol % or greater; about 30 mol % or greater; about 40 mol % or greater; about 50 mol % or greater; or more preferably about 60% or greater and the ethylene content of the C₂-rich effluent **124** can be about 10 mol % or greater; about 20 mol % or greater; about 30 mol % or greater; about 40 mol % or greater; about 50 mol % or greater; or more preferably about 60 mol % or greater.

[0120] FIG. 2 is a block flow diagram depicting an illustrative C₂ production and separation process **200** having one or more oxidative coupling of methane (OCM) reactors **102**, one or more separation units **104**, and one or more pretreatment units **202**. The one or more pretreatment units **202** are useful in removing contaminants and other undesirable compounds from the compressed OCM product gas **118** to provide a cleaned, compressed, OCM product gas **204**. For

example, water and carbon dioxide, both of which can freeze during a cryogenic process within the one or more separation units **104** may be removed from the compressed OCM product gas **118** in one or more pretreatment units **202**. Although depicted as a single entity in FIG. 2, the one or more pretreatment units **202** can include multiple unit operations each targeting the reduction of the amount of one or more contaminants present within the compressed OCM product gas **118**.

[0121] The compressed OCM product gas **118** can be introduced to the one or more pretreatment units **202** to remove one or more undesired components present in the compressed OCM product gas **118**. For example, all or a portion of the carbon dioxide present within the compressed OCM product gas **118** can be removed within the one or more pretreatment units **202**. Numerous methods of reducing the amount of carbon dioxide within the compressed OCM product gas **118** may be used. For example, the carbon dioxide level within the compressed OCM product gas **118** may be reduced by contacting the compressed OCM product gas **118** with a solution containing one or more amines such as monoethanolamine (MEA). In at least some embodiments at least a portion of the steam produced as a byproduct from the one or more OCM reactors can be used to facilitate the removal of carbon dioxide **206** from the compressed OCM gas **118** to provide the cleaned, compressed OCM product gas **204**. For example, byproduct steam may be useful in the thermal regeneration of caustic that has been converted to calcium carbonate in a carbon dioxide scrubber. In exemplary embodiments, the carbon dioxide content of the cleaned, compressed OCM product gas **204** can be about 20 ppm or less; about 10 ppm or less; or more preferably about 5 ppm or less.

[0122] Additionally, all or a portion of the water **208** present in the compressed OCM gas **118** as a water vapor can be removed within the one or more pretreatment units **202**. Numerous methods of reducing water vapor levels within the compressed OCM product gas **118** may be used. For example, the amount of water in the form of water vapor within the compressed OCM product gas **118** may be reduced using a thermal swing adsorption (TSA) process such as a multi-column TSA process enabling continuous water vapor removal and adsorbent bed regeneration. In at least some embodiments at least a portion of the steam produced as a byproduct from the one or more OCM reactors can be used to facilitate the regeneration of the adsorbent beds within a TSA process. In exemplary embodiments, the water vapor content of the cleaned, compressed OCM product gas **204** can be about 0.05 mol % or less; about 0.01 mol % or less; or more preferably about 0.001 mol % or less.

[0123] In at least some implementations, the pretreatment unit **202** may include one or more systems, devices, or processes to optionally remove at least a portion of any acetylene present in the OCM product gas **118**. In other implementations, the pretreatment unit **202** may include one or more systems, devices, or processes to optionally convert at least a portion of any acetylene present in the OCM product gas **118** to one or more preferred chemical species. For example, in at least some implementations, all or a portion of the OCM product gas **118** may be passed through an acetylene reactor where at least a portion of the acetylene present in the OCM product gas **118** can be selectively, catalytically hydrogenated to ethylene.

[0124] FIG. 3 is a basic process flow diagram depicting a methane based C_2 production and separation process **300** including a first separator **302** providing the C_2 -rich effluent **124** and a methane/nitrogen gas and a second separator **304** providing the methane-rich effluent **124** and the nitrogen-rich effluent **122**. In the embodiment illustrated in FIG. 3, the temperature of the compressed OCM product gas **118** is reduced using one or more heat exchangers **306**. The temperature of the compressed OCM product gas **118** may be lowered through the use of an external cooling media, a relatively cool process stream, or combinations thereof. Reducing the temperature of the OCM product gas **118** will condense at least a portion of the higher boiling point components in the compressed OCM product gas **118**, including at least a portion of the C_2 and heavier hydrocarbons present in the compressed OCM product gas **118**.

[0125] At least a portion of the condensed high boiling point components can be separated from the compressed OCM product gas **118** using one or more liquid/gas separators, such as knockout drums **308** to provide an OCM product gas condensate **310** and a compressed OCM product gas **312**. The OCM product gas condensate **310** is introduced to the first separator **302** and at least a portion **314** of the compressed OCM product gas **312** can be introduced to one or more turboexpanders **316**. The isentropic expansion of the compressed OCM product gas **314** within turboexpanders **316** can produce shaft work useful for driving one or more compressors or other devices in the separation unit **104**. The isentropic expansion of the compressed OCM product gas **314** with the turboexpanders reduces the temperature of the compressed OCM product gas **318** that exits from the one or more turboexpanders. The compressed OCM product gas **318** from the one or more turboexpanders **316** is introduced to the first separator **302**.

[0126] The first separator **302** can be any system, device or combination of systems and devices suitable for promoting the separation of C_2 and heavier hydrocarbons from a gas stream comprising mainly nitrogen and methane. For example, cryogenic distillation at a relatively high temperature may be used to promote the separation of C_2 and heavier hydrocarbons from a gas comprising mainly nitrogen and methane. The C_2 -rich effluent **124** is withdrawn from the first separator **302** and a mixed nitrogen/methane containing gas mixture **320** is also withdrawn from the first separator **302**. The nitrogen content of the nitrogen/methane containing gas mixture **320** withdrawn from the first separator **302** can be about 95 mol % or less; about 85 mol % or less; about 75 mol % or less; about 55 mol % or less; about 30 mol % or less. The balance of the nitrogen/methane gas mixture **320** comprises principally methane with small quantities of hydrogen, carbon monoxide, and inert gases such as argon.

[0127] In at least some embodiments, the first separator **302** may be referred to as a “demethanizer” based on its ability to separate methane from C_2 and higher hydrocarbons. An exemplary first separator **302** is provided by a vertical distillation column operating at below ambient temperature and above ambient pressure. The operating temperature and pressure within the first separator **302** can be established to improve the recovery of the desired C_2 hydrocarbons in the C_2 -rich effluent **124**. In exemplary embodiments, the first separator **302** can have an overhead operating temperature of from about -260°F . (-162°C .) to about -180°F . (-118°C .); about -250°F . (-157°C .) to about -190°F . (-123°C .); about -240°F . (-151°C .) to

about -200°F. (-129°C.); or more preferably from about -235°F. (-148°C.) to about -210°F. (-134°C.) and an bottom operating temperature of from about -150°F. (-101°C.) to about -50°F. (-46°C.); about -135°F. (-93°C.) to about -60°F. (-51°C.); from about -115°F. (-82°C.) to about -70°F. (-57°C.); or more preferably about -100°F. (-73°C.) to about -80°F. (-62°C.). In exemplary embodiments, the first separator **302** can be at an operating pressure of from about 30 psig (205 kPa) to about 130 psig (900 kPa); about 40 psig (275 kPa) to about 115 psig (790 kPa); about 50 psig (345 kPa) to about 95 psig (655 kPa); or more preferably about 60 psig (415 kPa) to about 80 psig (550 kPa).

[0128] The temperature of at least a portion of the C_2 -rich effluent **124** from first separator **302** can be increased in one or more heat exchangers **322** using a heat transfer fluid, a warm process flow stream, or a combination thereof. The one or more heat exchangers **322** can include any type of heat exchange device or system including, but not limited to one or more plate and frame, shell and tube, or the like. After exiting the one or more heat exchangers **322**, in exemplary embodiments, the temperature of the C_2 -rich effluent **124** can be about 50°F. (10°C.) or less; about 25°F. (-4°C.) or less; about 0°F. (-18°C.) or less; about -25°F. (-32°C.) or less; or about -50°F. (-46°C.) or less and the pressure can be about 130 psig (900 kPa) or less; about 115 psig (790 kPa) or less; about 100 psig (690 kPa) or less; or more preferably about 80 psig (550 kPa) or less.

[0129] The temperature of the nitrogen/methane containing gas mixture **320** withdrawn from the first separator **302** can be lowered in one or more heat exchangers **324** using one or more refrigerants, one or more relatively cool process flows, or combinations thereof. The one or more heat exchangers **324** can include any type of heat exchange device or system including, but not limited to one or more plate and frame, shell and tube, or the like. The cooled nitrogen/methane gas mixture **320** exiting one or more heat exchangers **324** is introduced to the second separator **304**.

[0130] In some embodiments a portion **326** of the OCM product gas **312** removed from the knockout drum **308** and not introduced to the one or more turboexpanders **316** can be cooled using one or more heat exchangers **328**. The one or more heat exchangers **328** can include any type of heat exchange device or system including, but not limited to one or more plate and frame, shell and tube, or the like. The temperature of the portion **326** of the OCM product gas **312** can be decreased using one or more refrigerants, one or more relatively cool process flows, or combinations thereof. The cooled portion **326** of the OCM product gas **312**, containing a mixture of nitrogen and methane is introduced to the second separator **304**.

[0131] The second separator **304** can be any system, device or combination of systems and devices suitable for promoting the separation of methane from nitrogen. For example, cryogenic distillation at a relatively low temperature can be used to promote the separation of methane from nitrogen in a gas stream. Conditions within the second separator **304** promote the condensation of methane and the separation of liquid methane from the gaseous nitrogen within the second separator **304**. The liquid methane containing methane-rich effluent **120** is withdrawn as a liquid from the second separator **304** and the nitrogen-rich effluent **122** is withdrawn as a gas from the second separator **304**. An exemplary second separator **304** is provided by a vertical

distillation column operating significantly below ambient temperature and above ambient pressure. The operating temperature and pressure within the second separator **302** can be established to improve the separation of liquid methane as the methane-rich effluent **120** from the gaseous nitrogen as the nitrogen-rich effluent **122**. For example, the second separator **304** can have an overhead operating temperature of from about -340°F. (-210°C.) to about -240°F. (-151°C.); about -330°F. (-201°C.) to about -250°F. (-157°C.); about -320°F. (-196°C.) to about -260°F. (162°C.); about -310°F. (-190°C.) to about -270°F. (-168°C.); or more preferably about -300°F. (-184°C.) to about -280°F. (-173°C.) and a bottom operating temperature of from about -280°F. (-173°C.) to about -170°F. (-112°C.); about -270°F. (-168°C.) to about -180°F. (-118°C.); about -260°F. (-162°C.) to about -190°F. (-123°C.); about -250°F. (-159°C.) to about -200°F. (-129°C.); or more preferably about -240°F. (-151°C.) to about -210°F. (-134°C.). In exemplary embodiments, the second separator **304** can be at an operating pressure of from about 85 psig (585 kPa) or less; about 70 psig (480 kPa) or less; about 55 psig (380 kPa) or less; or more preferably about 40 psig (275 kPa) or less.

[0132] The temperature of at least a portion of the methane-rich effluent **120** from the second separator **304** can be increased using one or more heat exchangers **330**. In at least some instances, one or more compressors may be used to increase the pressure and temperature of the methane-rich effluent **120** from the second separator **304** prior to recycling at least a portion of the compressed methane-rich effluent **304** to the feedstock gas/oxygen containing gas mixture **110**. The one or more heat exchangers **330** can include any type of heat exchange device or system including, but not limited to one or more plate and frame, shell and tube, or the like. The temperature of the methane-rich effluent **120** may be increased in heat exchangers **330** using a heat transfer fluid, a warm process flow, or a combination thereof. After exiting the one or more heat exchangers **330**, in exemplary embodiments the temperature of the methane-rich effluent **120** can be about 125°F. (52°C.) or less; about 100°F. (38°C.) or less; or more preferably about 90°F. (32°C.) or less and the pressure of the methane-rich effluent **120** can be about 150 psig (1035 kPa) or less; about 100 psig (690 kPa) or less; or more preferably about 50 psig (345 kPa) or less. In an embodiment in accordance with FIG. 3, at least a portion of the methane-rich effluent **120** can be recycled to the feedstock gas **112**, the feedstock gas/oxygen containing mixture **110**, the compressed oxygen containing gas, or to the one or more OCM reactors **102**.

[0133] The temperature of at least a portion of the nitrogen-rich effluent **122** can be increased using one or more heat exchangers **332**. The one or more heat exchangers **332** can include any type of heat exchange device or system including, but not limited to one or more plate and frame, shell and tube, or the like. The temperature of the nitrogen-rich effluent **122** may be increased in heat exchangers **332** using a heat transfer fluid, a warm process flow, or a combination thereof. After exiting the one or more heat exchangers **332**, in exemplary embodiments, the temperature of the nitrogen-rich effluent **122** can be about 125°F. (52°C.) or less; about 100°F. (38°C.) or less; or more preferably about 90°F. (32°C.) or less and the pressure of the nitrogen-rich effluent **122** can be about 150 psig (1035

kPa) or less; about 100 psig (690 kPa) or less; or more preferably about 50 psig (345 kPa) or less.

[0134] Although described above for brevity and clarity as independent heat exchange devices, the one or more heat exchangers 306, 322, 324, 328, 330, and 332 may be integrated into one or more composite heat exchange devices permitting, where appropriate, heat exchange between process flows of differing temperatures.

[0135] FIG. 4 is a basic process flow diagram depicting a methane based C₂ production and separation process 400 including compressed OCM product gas 114 pretreatment, a first separator 302 providing the C₂-rich effluent 124 and a methane/nitrogen gas and a second separator 304 providing the methane-rich effluent 124 and the nitrogen-rich effluent 122. In some embodiments, the compressed OCM product gas 114 can be introduced to a carbon dioxide removal treatment system 402. Carbon dioxide removal treatment system can comprise systems suitable for removing carbon dioxide from OCM product gas 114. In some embodiments, an ethanolamine-based carbon dioxide removal process can be used to scrub carbon dioxide from the compressed OCM product gas 114. The spent ethanolamine solution can be regenerated via heating thereby providing a recyclable carbon dioxide scrubbing solution. In other embodiments, a caustic-based carbon dioxide removal process can be used to scrub carbon dioxide from the compressed OCM product gas 114. In some instances, the sodium carbonate formed by scrubbing the carbon dioxide from the compressed OCM product gas 114 can be reacted with calcium hydroxide to form calcium carbonate and regenerate the caustic for recycle to the carbon dioxide removal treatment system 402.

[0136] The compressed OCM product gas 114 can also be introduced to a water removal system 404 that includes systems for removing water from OCM product gas 114. In some embodiments, the water removal system can include a thermal swing adsorption (TSA) system having at least two TSA columns to provide continuous water removal capability. Further details of exemplary TSA water removal systems have been described above.

[0137] FIG. 5 is a process flow diagram depicting a separation process 500 useful within one or more separation units 104 to separate the cleaned, compressed OCM product gas 204, according to one illustrated embodiment. As depicted in FIG. 5, heat exchange between various process streams is used to provide process heating and cooling as needed. Importantly, the adiabatic expansion of one or more process gasses coupled with the use of process heat exchange can minimize or even eliminate the requirement for the supply of external refrigeration to the separation process 500. In some instances, for example where purified or separated oxygen provides at least a portion of the oxygen containing gas 106, insufficient gas volume within the separation unit 104 may serve to limit the cooling effect realized by the adiabatic expansion of process gas within the separation unit 104. In such embodiments, external cooling, for example cooling from a cryogenic process providing the oxygen containing gas 106 may be used to provide at least a portion of the cooling within the separation unit 104.

[0138] In at least some embodiments, the pressure of the methane-rich effluent 120 withdrawn from the second separator 304 may be adjusted to provide a methane-rich effluent at two or more pressures. Such an arrangement may be advantageous for example, when a first portion 502 of the methane-rich effluent 120 is intended for distribution within

a commercial or industrial distribution network operating at a relatively low pressure and a second portion 504 of the methane-rich effluent 120 is intended for injection into a transport pipeline operating at a relatively high pressure. For example, the pressure of the first portion 502 of the methane-rich effluent 120 may be reduced to a pressure of from about 5 psig (35 kPa) to about 30 psig (205 kPa) by passing portion 502 of the methane-rich effluent 120 through a pressure reduction device such as a pressure reducing valve 506. The pressure of the second portion 504 of the methane-rich effluent 120 may be increased to a pressure of from about 30 psig (205 kPa) to about 100 psig (690 kPa) by passing portion 504 of the methane-rich effluent 120 through a pressure increasing device such as a fluid mover 508.

[0139] The cleaned, compressed OCM product gas 204 is introduced to the separation process 500. Recall, the OCM product gas exiting the one or more OCM reactors 102 is at an elevated temperature. While the OCM product gas is cooled, the temperature of the OCM product gas entering the separation process 500 remains at a relatively warm temperature, for example between about 50° F. (10° C.) and 150° F. (66° C.). Conversely, the C₂-rich effluent 124 withdrawn from the first separator 302 is typically at a relatively cool temperature, for example between about -150° F. (-101° C.) and about -80° F. (-62° C.). The first and second portions 502, 504 of the methane-rich effluent 120 and the nitrogen-rich effluent 122 withdrawn from the second separator 304 are also typically at relatively cool temperatures, for example between -340° F. (-207° C.) and about -170° F. (-112° C.). By thermally contacting the relatively warm cleaned, compressed OCM product gas 204 with the relatively cool C₂-rich effluent 124, first and second portions 502, 504 of the methane-rich effluent 120 and the nitrogen-rich effluent 122 in a first heat exchange device 510, the temperature of the cleaned, compressed OCM product gas 204 can be decreased and the temperature of the effluent streams increased. The first heat exchange device 510 can be any type, size, or shape heat exchange device capable of transferring heat between three or more components.

[0140] Recall from FIG. 3 the OCM product gas 312 removed from the knockout drum 308 can be apportioned or otherwise separated into a first portion 314 that is introduced to the one or more turboexpanders 316 and a second portion 326 that is ultimately introduced to the second separator 304. The adiabatic expansion of the cleaned, compressed OCM product gas 204 within the knockout drum 308 reduces the temperature of the OCM product gas 312 exiting drum 308. Thus, the temperature of the second portion of the OCM product gas 326 will be at a lower temperature than the cleaned, compressed OCM product gas 204 entering knockout drum 308.

[0141] By thermally contacting the relatively warm cleaned, compressed OCM product gas 204 and the second portion of the OCM product gas 326 with the relatively cool first and second portions 502, 504 of the methane-rich effluent 120 and the nitrogen-rich effluent 122 in a second heat exchange device 512, the temperature of the cleaned, compressed OCM product gas 204 and the second portion of the OCM product gas 326 can be further decreased and the temperature of the effluent streams increased. The second heat exchange device 512 can be any type, size, or shape heat exchange device capable of transferring heat between three or more components.

[0142] Cooling the second portion of the OCM product gas **326** can form a second OCM product gas condensate within the second portion of the OCM product gas **326**. The second portion of the OCM product gas **326** can be introduced to a liquid/gas separation device, such as a knockout drum **514** where the second OCM product gas condensate **516** is removed and returned to the first separator **302**, for example as a reflux to the first separator **302**. The OCM product gas **518** is withdrawn from the drum **514** and introduced to the second separator **304**.

[0143] In some embodiments, by thermally contacting the relatively warm OCM product gas **518** and the nitrogen/methane gas mixture **320** withdrawn from the first separator **302** with the relatively cool first and second portions **502**, **504** of the methane-rich effluent **120** and the nitrogen-rich effluent **122** from second separator **304** in a third heat exchange device **520**, the temperature of the OCM product gas **518** and the nitrogen/methane gas mixture **320** can be further decreased and the temperature of the effluent streams increased. The third heat exchange device **512** can be any type, size, or shape heat exchange device capable of transferring heat between three or more components.

[0144] In at least some embodiments, the pressure of the C₂-rich effluent **124** withdrawn from the first separator **302** can be increased, for example through the use of one or more fluid movers **522**. The C₂-rich effluent **124** contains a mixture of ethane, ethylene and heavier hydrocarbons such as propane, butane, pentane and hexane. In at least some embodiments, all or a portion of the C₂-rich effluent **124** can be fractionated or otherwise separated, for example within a C₂ separation process or column (e.g. a “de-ethanizer”) to provide at least an ethylene-rich effluent and an ethane-rich effluent. The ethylene-rich effluent can provide either a feedstock to a subsequent process or a fungible product. All or a portion of the ethane may be recycled back to the feedstock gas **112**.

[0145] FIG. 6 is a process flow diagram depicting another separation process **600** within one or more separation units **104** to separate the cleaned, compressed OCM product gas **204** into desired fractions, according to one illustrated embodiment. As depicted in FIG. 6, in addition to heat exchange between various process streams to provide process heating and cooling as needed, heat exchange is also useful for providing one or more reboiler loops (i.e., thermal energy inputs) to the first separator **302** and the second separator **304**. Additionally, the nitrogen/methane gas mixture **320** from the first separator **302** and the OCM product gas **518** from knockout drum **514** may also provide one or more thermal contributions to the third heat exchanger **520**.

[0146] In at least some embodiments, the OCM product gas **518** withdrawn from the knockout drum **514** is introduced to a second knockout drum **602**. Non-condensed OCM product gas **604** is withdrawn from the second knockout drum **602**. The temperature of the OCM product gas **604** can be reduced in the third heat exchanger **520** prior to introducing the OCM product gas **604** to the second separator **304**. Any OCM product gas condensate **606** in the second knockout drum **602** is withdrawn and introduced to a third knockout drum **608**.

[0147] In at least some embodiments, the nitrogen/methane gas mixture **320** can be withdrawn from the first separator **302** and introduced to the third heat exchanger **520** where a portion of the nitrogen/methane gas mixture **320** can condense. Any condensate present in either or both the

nitrogen/methane gas mixture **320** and the OCM product gas condensate **606** are separated in the third knockout drum **608**. The gas **610** within the third knockout drum **608**, comprising the nitrogen/methane gas mixture **320** and any OCM product gas from the OCM product gas condensate **606** are withdrawn from the third knockout drum **608**. The temperature of the relatively warm gas **610** is increased using the third heat exchanger **520** prior to introducing the gas **610** to the second separator **304**. Similarly, relatively warm condensate **612** from the third knockout drum **608** is withdrawn from the drum **608** and the temperature of the condensate **612** increased using the third heat exchanger **520** prior to introducing the condensate **612** to the second separator **304**.

[0148] In some embodiments, the thermal efficiency of the separation unit **104** may be improved by the transfer of thermal energy (i.e. heat) from the first heat exchanger **510** and the second heat exchanger **512** to the first separator **302** via reboiler loops **614** and **616**, respectively. Similarly, additional thermal efficiency may be realized by the transfer of thermal energy (i.e. heat) from the third heat exchanger **520** to the second separator **304** via reboiler loop **618**. In some embodiments, the thermal energy may be transferred between the heat exchangers and the separators using a closed loop heat transfer fluid. In other embodiments, the liquid present in the separator may be withdrawn and passed through the respective heat exchanger. In yet other embodiments, a portion of the first and second heat exchangers **510**, **512** may be partially or completely disposed within the first separator **302** and a portion of the third heat exchanger **520** may be partially or completely disposed within the second separator **304**.

[0149] The process flow diagram shown in FIG. 7 provides a more detailed breakdown of the thermal conservation process **700** that occurs in the first heat exchanger **510**, the second heat exchanger **512**, and the third heat exchanger **520**, according to one implementation. The thermal transfer processes occurring in each of the first heat exchanger **510**, the second heat exchanger **512**, and the third heat exchanger **520** are described in greater detail in Tables 1, 2, and 3 that follow. In the following tables, the term “hot stream” refers to a gas, liquid, or combination thereof whose thermal energy or temperature decreases as the gas, liquid, or combination thereof passes through the heat exchanger. In the following tables, the term “cold stream” refers to a gas, liquid, or combination thereof whose thermal energy or temperature increases as the gas, liquid, or combination thereof passes through the heat exchanger. For convenience and ease of description, each of heat exchangers **510**, **512**, and **520** are broken into a number of thermal cells in the following tables. One of ordinary skill in the chemical engineering art would readily appreciate that such cells may be freely added, removed or changed between heat exchangers to provide alternate levels of thermal conservation provided by the thermal conservation process **700**. Although only one cold stream and one hot stream are shown as included in each thermal cell, one of ordinary skill in the chemical engineering arts would readily appreciate that more than two streams (e.g., one hot stream and two cold streams, etc.) could be readily passed through a single thermal cell.

TABLE 1

HEAT EXCHANGER 510 THERMAL CELLS				
Cell ID	#	Cold Gas/Liquid	#	Hot Gas/Liquid
710a	122	Nitrogen rich effluent	204	OCM product gas
710b	502	1 st methane rich effluent	204	OCM product gas
710c	504	2 nd methane rich effluent	204	OCM product gas
710d	124	C ₂ -rich effluent	204	OCM product gas
710e	614	302 Reboiler loop	204	OCM product gas

TABLE 2

HEAT EXCHANGER 512 THERMAL CELLS				
Cell ID	#	Cold Gas/Liquid	#	Hot Gas/Liquid
712a	122	Nitrogen rich effluent	204	OCM product gas
712b	502	1 st methane rich effluent	204	OCM product gas
712c	504	2 nd methane rich effluent	204	OCM product gas
712d	616	302 Reboiler loop	204	OCM product gas
712e	122	Nitrogen rich effluent	326	OCM product gas fraction
712f	502	1 st methane rich effluent	326	OCM product gas fraction
712g	504	2 nd methane rich effluent	326	OCM product gas fraction

TABLE 3

HEAT EXCHANGER 520 THERMAL CELLS				
Cell ID	#	Cold Gas/Liquid	#	Hot Gas/Liquid
720a	122	Nitrogen rich effluent	610	K/O drum gas
720b	122	Nitrogen rich effluent	518	OCM product gas
720c	122	Nitrogen rich effluent	604	Non-cond. OCM prod. gas
720d	504	2 nd methane rich effluent	320	N ₂ /CH ₄ gas mixture
720e	504	2 nd methane rich effluent	612	Condensate
720f	502	1 st methane rich effluent	612	Condensate
720g	122	Nitrogen rich effluent	612	Condensate

[0150] The block flow diagram 800 depicted in FIG. 8 shows an optional post-treatment system 802 to which at least a portion of the C₂-rich effluent 124 is introduced. In at least some instances, the post-treatment system 802 may include any number of unit operations. For example, the post-treatment system 802 may include one or more devices, systems, or processes to provide an ethylene-rich effluent 804. Such an ethylene-rich effluent 804 may be useful in any number of subsequent processes, for example an oligomerization or catalytic polymerization process to produce a liquid gasoline product commonly referred to as polygas.

[0151] In at least some implementations, the post-treatment system 802 includes any number of systems, devices, or processes for reducing the quantity of any acetylene in the C₂-rich effluent 124. In at least some situations, such reduction may occur by removing as an acetylene-rich effluent 806 at least a portion of any acetylene present in the C₂-rich effluent 124. In at least some situations, such reduction may occur by converting at least a portion of any acetylene present in the C₂-rich effluent 124 to one or more preferred chemical species. In at least some implementations, the acetylene concentration in the C₂-rich effluent 124 can be reduced to less than about 1 part per million by volume

(ppmv); less than about 3 ppmv; less than about 5 ppmv; or less than about 10 ppmv after removal or conversion in the post-treatment system 802.

[0152] In at least some instances, the C₂-rich effluent 124 may be further separated the post-treatment system 802. The C₂-rich effluent 124 may include a number of chemical species that includes a mixture of ethane, ethylene, and C₃₊ hydrocarbons. In at least some implementations, the ethane, ethylene, and C₃₊ hydrocarbons may be partially or wholly separated or otherwise isolated in the post-treatment system 802. The separation of the C₂-rich effluent 124 into a ethane, ethylene, and C₃₊ can provide at least the ethylene-rich effluent 804, an ethane-rich effluent 808, and a C₃₊-rich effluent 810. In at least some implementations, all or a portion of the C₂-rich effluent 124 may be introduced to one or more systems, devices, or processes in which ethylene may be segregated, removed or otherwise isolated to provide the ethylene-rich effluent 804. In at least some instances, the ethylene-rich effluent 804 may include the overhead product of a distillation or cryogenic distillation process, for example a distillation process including at least one distillation column that is colloquially known within the chemical arts as a “C₂ Splitter” that operates at a reduced temperature and an elevated pressure. In such instances, the ethylene-rich effluent 804 so produced may have an ethylene concentration of about 75 mole percent (mol %) or more; about 80 mol % or more; about 85 mol % or more; about 90 mol % or more; about 95 mol % or more; about 99 mol % or more; or about 99.9 mol % or more.

[0153] In at least some implementations, the mixture of ethane and C₃₊ hydrocarbons remaining after the removal of at least a portion of the ethylene present in the C₂-rich effluent 124 may be introduced to one or more systems, devices, or processes in which all or a portion of the ethane may be segregated, removed or otherwise isolated to provide the ethane-rich effluent 808. In at least some instances, the ethane-rich effluent 808 may include at least a portion of the overhead product of a distillation or cryogenic distillation process, for example a distillation process that includes at least one distillation column operating at a reduced temperature and an elevated pressure. In such instances, the ethane-rich effluent 808 so produced may have an ethane concentration of about 75 mole percent (mol %) or more; about 80 mol % or more; about 85 mol % or more; about 90 mol % or more; about 95 mol % or more; about 99 mol % or more; or about 99.9 mol % or more. In such instances, the C₃₊-rich effluent 810 may include at least a portion of the bottoms from the ethane separation process. In such instances, the C₃₊-rich effluent 810 so produced may have a C₃₊ hydrocarbon concentration of about 75 mole percent (mol %) or more; about 80 mol % or more; about 85 mol % or more; about 90 mol % or more; about 95 mol % or more; about 99 mol % or more; or about 99.9 mol % or more.

Prophetic Example

[0154] Referring to FIG. 2, the following prophetic example illustrates a compositional analysis of an exemplary OCM process in accordance with embodiments disclosed herein with separation of the C₂-rich effluent 124, the nitrogen-rich effluent 122 and the methane-rich effluent 120.

Ref #	Flow (klb/hr)	C ₁ Mol %	N ₂ Mol %	O ₂ Mol %	H ₂ O Mol %	CO Mol %	CO ₂ Mol %	C ₂ Mol %	C ₂ = Mol %
106	36.4	0	78	21	0	0	0	0	0
112	5.8	99	0	0	0	0	0	0	0
110	56.9	48	39	10	0	0	0	0	0
114	56.9	37	39	0	12	1.1	2.4	2	1.8
204	46.9	44	47	0	0	1.3	0	2.4	2.1
120	15.5	97	0.5	0	0	0.5	0	0	0
122	28.6	1	91	0	0	2.2	0	0	0
124	2.8	1	0	0	0	0	0	52	43

[0155] Although described in the context of an oxidative coupling of methane (OCM) process, the disclosed systems and methods can be applied to the separation of a similarly composed C₂-rich effluent **124** from processes similar to or different from the OCM production process described in detail herein. As an example, another process providing a gaseous effluent similar to the OCM product gas **114** is provided by an oxidative dehydrogenation of ethane to form ethylene using air as the oxygen comprising feed gas.

1.-55. (canceled)

56. A process for producing hydrocarbon compounds via oxidative coupling methane (OCM), comprising:

- (a) directing a feed stream comprising methane and oxygen into an OCM reactor to generate an OCM product gas comprising hydrocarbon compounds with two or more carbon atoms (C₂₊ compounds);
- (b) separating at least a portion of said OCM product gas into a first stream and a second stream;
- (c) expanding at least a portion of said first stream substantially isentropically to produce an expanded first stream; and
- (d) directing said at least a portion of said first stream expanded in (c) and said second stream into a separations unit to generate a C₂-rich effluent comprising at least a portion of said C₂₊ compounds and an effluent comprising methane.

57. The process of claim **56**, further comprising, between (a) and (b), condensing at least a portion of said C₂₊ compounds in said OCM product gas by reducing a temperature of said OCM product gas using one or more heat exchangers.

58. The process of claim **57**, wherein (b) further comprises, directing said at least a portion of said OCM product gas into one or more liquid-gas separators to separate said at least a portion of said OCM product gas into said first stream and said second stream.

59. The process of claim **58**, wherein said first stream comprises at least a portion of said methane, and wherein said second stream comprises at least a portion of condensed C₂₊ compounds.

60. The process of claim **58**, wherein (b) further comprises, expanding said at least a portion of said OCM product gas substantially adiabatically in said one or more liquid-gas separators.

61. The process of claim **56**, further comprising, between (a) and (b), directing said OCM product gas into a carbon dioxide removal treatment unit to reduce a carbon dioxide content of said OCM product gas.

62. The method of claim **61**, wherein said carbon dioxide content of said OCM product gas is reduced to about 20 ppm or less.

63. The process of claim **56**, further comprising, between (a) and (b), directing said OCM product gas into a treatment unit to reduce a water vapor content of said OCM product gas.

64. The process of claim **63**, wherein said treatment unit comprises a thermal swing adsorption (TSA) process.

65. The process of claim **63**, wherein said water vapor content of said OCM product gas is reduced to about 0.01 mole percent or less.

66. The process of claim **56**, further comprising, directing an additional portion of said first stream and at least a portion of said effluent into an additional separations unit to generate a methane-rich effluent.

67. The process of claim **66**, wherein said methane-rich effluent has a methane content of at least about 90 mole percent.

68. The process of claim **66**, further comprising, directing at least a portion of said methane-rich effluent into said OCM reactor.

69. The process of claim **66**, further comprising, adjusting a pressure of said methane-rich effluent to produce one or more methane-rich streams at different pressures.

70. The process of claim **69**, wherein said one or more methane-rich streams comprise at least (i) a first methane-rich stream at a first pressure between about 5 pounds per square inch gauge (psig) and 30 psig, and (ii) a second methane-rich stream at a second pressure between about 30 psig and about 100 psig.

71. The process of claim **66**, wherein said separations unit is operated at a first temperature and a first pressure, and wherein said additional separations unit is operated at a second temperature lower than said first temperature and a second pressure lower than said first pressure.

72. The process of claim **56**, further comprising, (e) directing at least a portion of said C₂-rich effluent into an acetylene reactor that converts at least a portion of acetylene in said at least a portion of said C₂-rich effluent to ethylene.

73. The process of claim **56**, further comprising, (e) separating at least a portion of said C₂-rich effluent into an ethylene-rich effluent and an ethane-rich effluent.

74. The Process of claim **56**, wherein said C₂-rich effluent has an ethylene content of at least about 60 mole percent.

75. The Process of claim **56**, wherein said C₂-rich effluent has an ethane content of at least about 60 mole percent.

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